Analysis of freeform optical systems based on the decomposition of the total wave aberration into Zernike surface contributions

Dissertation
for the acquisition of the academic title

*doctor rerum naturalium* (Dr. rer. nat.)

submitted to the Council of the Faculty of Physics and Astronomy of the Friedrich-Schiller-Universität Jena

by

MSc. Mateusz Oleszko

born in Opole, Poland on 10.07.1988
Supervisors:

Major Supervisor: Prof. Dr. Herbert Gross
Associate Supervisor: Prof. Dr. Norbert Lindlein
Associate Supervisor: Prof. Dr. Fabian Duerr

Day of the Disputation: 09.04.2019
Abstract

The increasing use of freeform optical surfaces raises the demand for optical design tools developed for generalized systems. In the design process, surface-by-surface aberration contributions are of special interest. The expansion of the wave aberration function into the field- and pupil-dependent coefficients is an analytical method used for that purpose. An alternative numerical approach utilizing data from the trace of multiple ray sets is proposed. The optical system is divided into segments of the optical path measured along the chief ray. Each segment covers one surface and the distance to the subsequent surface. Surface contributions represent the change of the wavefront that occurs due to propagation through individual segments. Further, the surface contributions are divided with respect to their phenomenological origin into intrinsic induced and transfer components. Each component is determined from a separate set of rays. The proposed method does not place any constraints on the system geometry or the aperture shape. However, in this thesis only plane symmetric systems with near-circular apertures are studied. This enabled characterization of the obtained aberration components with Zernike fringe polynomials.

The application of the proposed method in the design process of the freeform systems is demonstrated. The analysis of Zernike surface contributions provides valuable insights for selecting the starting system with the best potential for correcting aberrations with freeform surfaces. Further, it helps in determining the effective location of a freeform element in a system. Consequently, it is possible to design systems corrected for Zernike aberrations of order higher than the order of coefficients used for freeform sag contributions, described with the same Zernike polynomial set.
This page is left blank intentionally.
Contents

Chapter 1 Introduction ........................................................................................................... 8

Chapter 2 Theory ......................................................................................................................................... 11
  2.1 Wave aberrations determined analytically ......................................................................................... 11
    2.1.1 Ray aberrations .......................................................................................................................... 11
    2.1.2 The total wave aberration ......................................................................................................... 12
    2.1.3 The expansion of the wave aberration function ......................................................................... 13
    2.1.4 Wave aberration coefficients in terms of Seidel sums ............................................................... 15
    2.1.5 Sixth-order wave aberration coefficients ................................................................................... 16
      2.1.5.1 Intrinsic aberrations ............................................................................................................ 17
      2.1.5.2 Induced aberrations ........................................................................................................... 18
    2.1.6 The wave aberration function in non-rotationally symmetric systems ...................................... 19
      2.1.6.1 Nodal aberration theory ..................................................................................................... 19
      2.1.6.2 Aberration fields of plane symmetric systems ................................................................. 21
    2.1.7 Pupil coordinates ........................................................................................................................ 22
  2.2 Wave aberrations determined numerically ......................................................................................... 24
    2.2.1 The optical path difference (OPD) formula .............................................................................. 24
    2.2.2 Alternative definition of surface contributions .......................................................................... 26
    2.2.3 First-order ray tracing .............................................................................................................. 27
      2.2.3.1 Grid distortion .................................................................................................................... 28
      2.2.3.2 Exit pupil shape ................................................................................................................ 28
    2.2.4 Pupil distortion – ray aiming .................................................................................................... 29
  2.3 Decomposition of the total wave aberration into Zernike fringe coefficients .................................. 30
  2.4 Freeform optics ................................................................................................................................... 34
  2.5 Tolerance sensitivity analysis ........................................................................................................... 35

Chapter 3 Novel method for decomposition of the total wave aberration ............................................. 38
  3.1 Intermediate references ..................................................................................................................... 38
    3.1.1 Reference spheres ..................................................................................................................... 38
    3.1.2 Intermediate images .................................................................................................................. 39
Acknowledgments

Zusammenfassung

Curriculum vitae

Publications

Ehrenwörtliche Erklärung
Chapter 1  Introduction

Before computers became available, lens designers were concentrated on developing tools to design multi-lens optical systems using simple hand calculation. The introduction of Seidel sums made the evaluation of primary aberrations of an optical system possible, based only on construction parameters and a trace of two paraxial rays. That enabled Petzval to design the first photographic lens corrected for all primary aberrations [1]. The Seidel sums method was further extended for aberrations of higher orders by Buchdahl [2].

Since the advent of computers the computational power became less of an issue enabling a trace of multiple real rays through a complete system. Thus, the evaluation of the total aberration with no limitation to an expansion order has been possible [3]. The lens designers have employed local optimization methods [4, 5] in the designing process obtaining well-corrected complex lens systems. Further, in order to explore the complete solution space of a design problem, different global optimization methods have been tested [6-9]. Nevertheless, it is still not possible to replace the work of a trained lens designer. Thus in parallel, analytical approach of expanding wave aberration function into field and pupil-dependent coefficients has been developed, providing valuable insights into potentials and limitations of a particular design solution. Currently, surface-by-surface aberration coefficients up to the sixth order are derived in the literature [10] for axially symmetric systems. The functionality of the approach has been further extended for the analysis of non-axially symmetric optical systems [11-13]. The analysis of aberration effects is of crucial importance in assessing the limitations and possibilities of various configurations, guiding the optimization process towards the best „as-built“ solution [14].

Development of ultraprecision diamond machining technologies enabled the manufacturing of surfaces with a varying azimuthal profile, the so-called freeforms. This has opened the possibility to build more compact systems with larger apertures and fields of view [15]. In order to fully benefit from the application of freeform elements, new mathematical representations to simulate freeform surfaces in the optical design software were introduced [16]. In the design stage, typically a set of polynomials is used to describe the complete surface.
Global surface representations assure convergence during the optimization process. Thus, new polynomial sets suitable for different aperture shapes and with different orthogonality properties [17-19] were developed. After the design stage, it is necessary to assess the performance of the „as-built“ freeform system. In this case local representations such as radial basis functions (RBF) appeared to be appropriate to reproduce the manufacturing artifacts [20].

Application of freeform elements in multi-lens imaging system raises an issue of where to place the freeform surface to be used most effectively. Strategies for placing freeforms to achieve significant improvement in the performance of multi-lens systems were therefore investigated by Liu in [21].

However, freeform surfaces appeared to be beneficial especially when applied in tilted mirror systems. Mirror systems typically consist of only a few surfaces and are non-axially symmetric in order to avoid central obscuration. Additionally, mirrors generate only monochromatic aberrations and therefore the choice of glasses is of no concern. Thus, freeform surfaces can be employed to develop compact tilted mirror systems with excellent imaging performance, large field of view (FOV) and low F# [15]. However, it is non-trivial to determine which starting system to choose and where to place the freeform element to obtain the best design. The knowledge of aberration generated in the system is very helpful in answering these questions. Thus, design strategies based on aberration theory have been developed in recent years.

One of the approaches presented in [22] is to iteratively identify the limiting aberration and to apply the correct term in the description of the freeform sag contribution. This approach is based on modifications to the aberration fields introduced by freeform surfaces derived from nodal aberration theory (NAT) [23]. The final image performance is then checked in the exit pupil using full field displays (FFDs) of Zernike aberrations obtained from ray-tracing data.

Another design procedure is to first design an appropriate axially symmetric starting system by using Gaussian brackets and Seidel aberration coefficients. Next, to apply tilt angles and derive the aberration coefficients of an unobscured system with NAT. In the last step freeform elements are introduced to correct the large arising, field-constant aberrations [24].

The aim of this thesis was to develop a new numerical method for determining surface-by-surface contributions to the total wave aberration that can be used to assist the design of freeform optical systems. This thesis is divided into three parts. In chapter 2, an overview of
the field of wave aberration theory is given. Both analytical and ray-tracing methods to
determine wave aberrations are introduced. In chapter 3, the new numerical approach to
determine wave aberrations utilizing data from the trace of multiple ray sets is described. The
total wave aberration is divided into surface contributions and further decomposed into
intrinsic, induced and transfer components. Each component is determined from a separate set
of rays and characterized by Zernike fringe coefficients. In chapter 4, Zernike aberration
coefficients are used to analyze the aberrations of freeform optical systems. The design strategy
based on the proposed method for tilted three-mirror systems is introduced. The potentials to
determine the most effective initial system and the location of the freeform element are
demonstrated. Further, functionalities of the tool in assisting the design of multi-lens systems
are shown.
Chapter 2  Theory

2.1  Wave aberrations determined analytically

This section serves as a brief introduction to the theory of aberrations of optical systems with circular apertures, based on the expansion of the wave aberration function. It is the established method for classifying aberrations with respect to the symmetry of the optical system. Further, the expansion of the wave aberration function allows distinguishing contributions from individual surfaces to the total wave aberration. The total wave aberration quantifies the deviation from first-order imagery, which can be modeled with respect to a selected convention of references. Notation employed in this section corresponds to the one used by Sasian in [25].

2.1.1  Ray aberrations

On top of the diffraction effect resulting from a finite aperture, the resolution of an optical system is limited due to the deviation from the ideal geometric imagery. The geometric transformation of a point between object and image planes is typically described with the Gaussian model. In this model each ray originating from the object plane passes through the entrance and exit pupil planes, which represent the transformation performed by an optical system, and intersects the image plane at the scaled coordinates. Thus, each ray can be described using vectors in two planes, namely the field vector and the pupil vector. In this approach, the normalized field vector \( \vec{H} \) is located on the object plane and defines the point source from which the ray set originates. The normalized pupil vector \( \vec{\rho} \) defines the coordinates of the point in which a particular ray intersects the exit pupil. In the first-order approximation, rays intersect the image plane and the entrance pupil plane at the equivalent coordinates. However, the real imagery of an optical system deviates from ideal geometric
transformation. Consequently, transverse aberrations in the image ($\Delta \vec{H}$) and the entrance pupil ($\Delta \vec{\rho}$) planes occur; see Figure 2-1.

![Figure 2-1](image.png)

Figure 2-1. A first-order ray illustrated with the dotted line travels with no transverse error. A real ray, shown with the solid line, usually travels on a path that deviates from the first-order ray [25].

Here only transverse aberrations of third and fifth order are considered.

### 2.1.2 The total wave aberration

In the approximation of the first order, each ray originating from a point in the object arrives at a scaled point in the image, travelling an optical path of the same length measured in the exit pupil. Nevertheless, if transverse aberrations are added, the optical path for each ray arriving on the exit pupil differs. Thus, deviation from the ideal imagery can be also expressed in terms of the error in optical path length ($OPL$). The $OPL$ is given by integrating the trajectory of a ray ($s$) traversing arbitrary points $P_0$ and $P_1$ in a medium with refractive index ($n$):

$$OPL = \int_{P_0}^{P_1} nds. \quad (2-1)$$

The surface of equal $OPL$’s is a wavefront. Thus, to determine the wavefront, one needs to trace an arbitrary set of rays originating from a single point in the object plane.

An ideal wavefront propagates along first-order rays and is a spherical or plane surface that converges to a point or infinity in the image space. An aberrated wavefront deviates from the ideal shape. The measure of this deviation in the image space is the total wave aberration. Further, the wavefront can be well-defined only if the boundary of the beam is unambiguously determined. This is possible in the mechanical aperture of the optical system. Analogously, the boundary of the beam is also unblurred in the entrance pupil plane and the exit pupil plane,
which are the images of the aperture in object and image space, respectively. Thus, the total wave aberration is defined in the exit pupil as a function of the normalized field and pupil vectors \( W(\vec{H}, \vec{p}) \). It quantifies the difference in the shape of the real wavefront and the corresponding ideal wavefront, represented by the reference sphere. This difference is calculated from the reference sphere to the wavefront along a real ray; see Figure 2-2.

![Figure 2-2](image)

Figure 2-2. The total wave aberration function \( W(\vec{H}, \vec{p}) \) defined as a difference in the shape of the real wavefront and the corresponding ideal wavefront measured along the real ray in the exit pupil plane.

In analogy, the wave aberration can be defined after each surface in the intermediate exit pupil, which is an image of the stop in intermediate image space. In this way an optical system is divided into subsystems each bounded by an associated entrance and exit pupil. Thus, contributions to the total wave aberration are defined in the exit pupils of individual surfaces.

### 2.1.3 The expansion of the wave aberration function

Any differentiable function can be approximated by series of coefficients assigned to power combinations of its variables, known as Taylor series. In principle an unknown function defined around a certain point in variable space is first approximated to be constant, then a linear combination, then squared, and so on. For a function \( f \) of a single variable \( x \) expanded around point \( x_0 \), one can write:

\[
f(x) = f(x_0) + f'(x_0)(x - x_0) + \frac{f''(x_0)(x-x_0)^2}{2} + \frac{f'''(x_0)(x-x_0)^3}{2 \cdot 3},
\]

which for \( x_0 = 0 \) can be noted as power series to the \( N^{th} \) order of approximation:
\[ f(x) = \sum_{n}^{N} a_n x^n. \quad (2-3) \]

The power series expansion is also employed to approximate the value of the wave aberration function \( W(\vec{H}, \vec{\rho}) \), which is a scalar function of four variables, \( \rho_x, \rho_y \) in the exit pupil and \( H_x, H_y \) in the object space. This is further simplified when invariance upon rotation around an optical axis is taken into account. There exist three combinations which are rotation invariant namely: \( H_x^2 + H_y^2, \rho_x H_x + \rho_y H_y, \rho_x^2 + \rho_y^2 \). Further, due to the symmetry, the orientation with respect to the optical axis can be neglected. This is best performed by changing to polar coordinates and replacing the mixed term with the cosine of an angle \( \phi \), between vectors \( \vec{H} \) and \( \vec{\rho} \). Thus, one can write the wave aberration function as an expansion with three variables:

\[
W(\vec{H}, \vec{\rho}) = W(H^2, r^2, Hr \cos \phi) = \sum_{s=1}^{N} \sum_{k,l,m} W_{k,l,m} H^k r^l \cos \phi^m = W_{000} + (W_{200} H^2 + W_{111} H r \cos \phi + W_{020} r^2)_{2^{nd\,order}} + (W_{400} H^4 + W_{311} H^3 r \cos \phi + W_{220} H^2 r^2 + W_{221} H^2 r^2 \cos^2 \phi + W_{131} H^3 r^3 \cos \phi + W_{040} r^4)_{4^{th\,order}} + (W_{600} H^6 + W_{511} H^5 r \cos \phi + W_{420} H^4 r^2 + W_{421} H^4 r^2 \cos^2 \phi + W_{331} H^3 r^3 \cos \phi + W_{332} H^3 r^3 \cos^3 \phi + W_{240} H^2 r^4 + W_{241} H^2 r^4 \cos^2 \phi + W_{151} H r^5 \cos \phi + W_{060} r^6)_{6^{th\,order}}, \quad (2-4)
\]

where \( s \) is a number of a surface, indices \( k, l, m \) represent powers of \( H, r \) and \( Hr \cos \phi \) respectively and coefficients are grouped according to the total order \( k + l \).

The expansion into wave aberration coefficients allows for the investigation of types of aberrations that may occur in axially symmetric optical systems [26]. Since the wave aberration function is derived from an integral of ray trajectories, its coefficients are of one degree higher than the corresponding transverse aberration coefficients. If the second-order coefficients of wave aberration function are equal to zero, the wave aberration describes the deviation from the ideal wavefront, centered upon a Gaussian image point. In this way a relation to the first-order approximation in terms of transverse aberration, is established. Further, wave aberration coefficients of order higher than the second can be divided into point-imaging aberrations (causing a loss in resolution) and image-shape aberrations (not influencing the resolution but deforming the shape of an image).

Since wave aberration function is analyzed in the exit pupil, only the dependency on the pupil term \( r^n \) together with the mixed term \( \cos^m \phi \) are explicitly revealed in its shape. This allows
for deliberate analysis of point-imaging aberrations, whereas image-shape aberrations are expressed only through the tilt and decenter with respect to the reference sphere. If azimuthal order \((m)\) of the pupil dependent coefficient is zero it represents the spherical-like aberration, which is completely symmetrical about the center of the pupil. In case the index \(m\) of the coefficient is equal to one, the aberration has a symmetry about the tangential plane and is called coma-like. If the aberration has two planes of symmetry \((m\) is equal to two) it is classified as astigmatic.

As mentioned, the total wave aberration is a function of two vectors and the sum of contributions obtained in intermediate exit pupils after each surface. Thus, for sake of simplicity of analytical derivations introduced in following sections, it is alternatively written with vector notation:

\[
W(\vec{H}, \vec{\rho}) = \sum_{s=1}^{N} \sum_{j,m,n} W_{k,l,m} (\vec{H} \cdot \vec{H})^{j} \cdot (\vec{H} \cdot \vec{\rho})^{m} \cdot (\vec{\rho} \cdot \vec{\rho})^{n}, \quad (2-5)
\]

where \(s\) is a number of a surface, indices \(j, m, n\) represent integer numbers related to indices \(k, l, m\) of Equation (2-4):

\[
j = \frac{k-m}{2}, \quad m = m, \quad n = \frac{l-m}{2}. \quad (2-6)
\]

This notation is attributed to Roland Shack.

### 2.1.4 Wave aberration coefficients in terms of Seidel sums

In practice the coefficients of the wave aberration function are derived from structural system parameters (refractive indices and radii of curvature) and first-order ray tracing data. Table 2-1 presents quantities necessary to derive the group of five, fourth-order aberration coefficients from Equation (2-4).

<table>
<thead>
<tr>
<th>Refraction invariant marginal ray</th>
<th>Refraction invariant chief ray</th>
<th>Lagrange invariant surface curvature</th>
<th>Petzval sum term</th>
</tr>
</thead>
<tbody>
<tr>
<td>(A = ni = nu + nhc)</td>
<td>(\tilde{A} = n\tilde{i} = n\tilde{u} + n\tilde{hc})</td>
<td>(\mathcal{K} = n\tilde{u}h - n\tilde{u}\tilde{h} = \tilde{A}h - \tilde{A}\tilde{h})</td>
<td>(p = c \cdot \Delta \left( \frac{1}{n} \right) )</td>
</tr>
<tr>
<td></td>
<td></td>
<td>(c = \frac{1}{r})</td>
<td></td>
</tr>
</tbody>
</table>

Table 2-1. Quantities derived from structural system parameters and first-order ray tracing data utilized in deriving the fourth-order wave aberration coefficients [25].
Where $n$ is a refractive index, $r$ is a radius of curvature, $i$ is an incidence angle, $u$ is a convergence angle and $h$ is an incidence height at the surface. The dashed symbols refer to the first-order chief ray and the ones without dash to the first-order marginal ray.

Historically, the fourth-order wave aberration coefficients in the exit pupil are derived from the so-called Seidel sums. Seidel sums are a group of formulas utilizing quantities introduced in Table 2-1 to first derive the aberration contributions of each surface and then to sum it over the complete system. The relation between Seidel sums and the fourth-order wave aberration coefficients is given in Table 2-2.

<table>
<thead>
<tr>
<th>Aberration</th>
<th>Wave aberration coefficient</th>
<th>Seidel sum</th>
</tr>
</thead>
<tbody>
<tr>
<td>Spherical aberration</td>
<td>$W_{040} = \frac{1}{8} S_I$</td>
<td>$S_I = - \sum_{s=1}^{N} \left( A^2 h \Delta \left( \frac{u}{n} \right) \right)_s$</td>
</tr>
<tr>
<td>Coma</td>
<td>$W_{131} = \frac{1}{2} S_{II}$</td>
<td>$S_{II} = - \sum_{s=1}^{N} \left( A \Delta \left( \frac{u}{n} \right) \right)_s$</td>
</tr>
<tr>
<td>Astigmatism</td>
<td>$W_{222} = \frac{1}{2} S_{III}$</td>
<td>$S_{III} = - \sum_{s=1}^{N} \left( A \Delta \left( \frac{u}{n} \right) \right)_s$</td>
</tr>
<tr>
<td>Field curvature (sagittal)</td>
<td>$W_{220} = \frac{1}{4} (S_{IV} + S_{III})$</td>
<td>$S_{IV} = -A^2 \sum_{s=1}^{N} P_s$</td>
</tr>
<tr>
<td>Distortion</td>
<td>$W_{311} = \frac{1}{2} S_V$</td>
<td>$S_V = - \sum_{s=1}^{N} \left( \frac{A}{A} \left[ A^2 P + \Delta \left( \frac{u}{n} \right) \right] \right)_s$</td>
</tr>
</tbody>
</table>

### 2.1.5 Sixth-order wave aberration coefficients

The wave aberration coefficients of the fourth order do not depend on a choice of the references and can be unambiguously assigned to the refraction on each surface [3] utilizing formulas from Subsection 2.1.4. They are in this way directly related to the third-order transverse error in intermediate image planes $\Delta H^{(3)}$. However, if higher-order aberrations are considered, the
accuracy of the approximation is increased and the transverse error of the pupil vector has to be taken into account.

In [27] Sasian discusses the strategy for correction of fourth- and sixth-order spherical aberration introduced by a single element. He concludes, that the higher-order aberrations can be controlled by a corrector lens system with a known ratio between intersection heights of the first-order marginal ray and a real, refracted marginal ray, through selecting an appropriate fourth-order contribution. This ratio is in other words a metric of the transverse pupil aberration on the corrector lens system introduced by an element under correction.

Consequently, by adding the sixth-order wave aberration coefficients, the third-order transverse pupil aberration $\Delta \rho^{(3)}$ is included. The transverse pupil aberration provides the mapping error between the entrance pupil and the exit pupil of each surface. This mapping error arises due to two effects, the refraction on the surface and the incoming aberrated wavefront.

If the transverse aberration is evaluated at the entrance pupil of each surface, it is possible to distinguish between these two effects. Thus, the sixth-order aberration coefficients can be divided into two categories namely, intrinsic and induced. This division was first mentioned by Hoffman [28] and further developed in [29].

### 2.1.5.1 Intrinsic aberrations

The intrinsic wave aberration is a deformation of an ideal wavefront after refraction on a surface evaluated independently on the rest of the system. In this way the sixth-order intrinsic aberration coefficients are an extension to the fourth-order coefficients taking into account the transverse pupil aberration introduced by individual surfaces. As an example, the formula for the sixth-order intrinsic spherical aberration of a single surface is considered [25]:

$$ W_{060} = W_{040} \left[ \frac{1}{2} \frac{h^2}{r^2} - \frac{1}{2} A \left( \frac{u}{m} + \frac{u}{n} \right) + 2 \frac{h}{r} u' \right], \quad (2-7) $$

where the impact on transverse pupil aberration for the pupil vector located on the exit pupil is present through the slope of an outgoing marginal ray in the last term $2 \frac{h}{r} u'$. 
Further, for a surface inside the complete system, a term arising upon propagation to the intermediate exit pupil, which is proportional to the chief ray height $\frac{\bar{h}}{h}$ [25], needs to be added. Thus, the complete expression is written as:

$$W_{060l} = W_{040} \left[ \frac{1}{2} \frac{h^2}{r^2} - \frac{1}{2} A \left( \frac{u'}{n'} + \frac{u}{n} \right) + 2 \frac{h}{r} u' \right] - \frac{8}{\mathcal{R}} W_{040} W_{040} \frac{\bar{h}}{h}. \quad (2-8)$$

The sixth-order intrinsic coefficients are therefore products of other aberration coefficients and the first-order ray properties. Table 2.3 shows formulas for all four, sixth-order intrinsic aberration coefficients with extended pupil dependency.

### Table 2.3. The sixth-order, intrinsic aberration coefficients with extended pupil dependency, derived from the fourth-order coefficients and the first-order ray properties.

<table>
<thead>
<tr>
<th>Aberration</th>
<th>Wave aberration coefficient</th>
</tr>
</thead>
<tbody>
<tr>
<td>sixth-order spherical aberration</td>
<td>$W_{060l} = W_{040} \left[ \frac{1}{2} \frac{h^2}{r^2} - \frac{1}{2} A \left( \frac{u'}{n'} + \frac{u}{n} \right) + 2 \frac{h}{r} u' \right] - \frac{8}{\mathcal{R}} W_{040} W_{040} \frac{\bar{h}}{h}$</td>
</tr>
<tr>
<td>sixth-order aperture coma</td>
<td>$W_{151} = 6 \frac{\bar{h}}{A} W_{060l} + W_{131} u'^2 + W_{151CC}$</td>
</tr>
<tr>
<td>oblique spherical aberration (tangential)</td>
<td>$W_{242l} = 12 \left( \frac{\bar{h}}{A} \right) ^2 W_{060l} + \frac{7}{2} W_{222} u'^2 - 3 W_{131} u' \bar{u}' + W_{242CC}$</td>
</tr>
<tr>
<td>un-named</td>
<td>$W_{333l} = 8 \left( \frac{\bar{h}}{A} \right) ^3 W_{060l} + 4 \left( \frac{\bar{h}}{A} \right) ^2 W_{151CC} + 3 \frac{\bar{h}}{A} W_{222} u'^2 + 2 \frac{\bar{h}}{A} W_{242CC}$</td>
</tr>
</tbody>
</table>

#### 2.1.5.2 Induced aberrations

The induced wave aberration arises due to incoming aberrations, accumulated from preceding surfaces, and the transverse pupil aberration measured at the entrance pupil of a surface. If the system of two surfaces is considered, with the pupil vector located at the exit pupil (see Figure 2-3), one can write the wave aberration function as the sum of surface contributions:
\[ W(\vec{H}, \vec{\rho}) = W_1(\vec{H}, \vec{\rho} + \vec{\Delta \rho}) + W_2(\vec{H}, \vec{\rho}) . \quad (2-9) \]

Due to lack of an incoming aberration the contribution from the first surface is of purely intrinsic type, therefore to the sixth order one can write [29]:

\[ W(\vec{H}, \vec{\rho}) = W_1^{(4)}(\vec{H}, \vec{\rho} + \vec{\Delta \rho}^{(3)}) + W_1^{(6I)}(\vec{H}, \vec{\rho}) + W_2^{(4)}(\vec{H}, \vec{\rho}) + W_2^{(6I)}(\vec{H}, \vec{\rho}). \quad (2-10) \]

The sixth-order induced terms \( W_2^{(6E)}(\vec{H}, \vec{\rho}) \) are obtained as an effect of the third-order transverse aberration on the entrance pupil of the second surface \( \vec{\Delta \rho}^{(3)} \) and the incoming fourth-order wave aberrations. Consequently, terms \( W_1^{(4)}(\vec{H}, \vec{\rho} + \vec{\Delta \rho}^{(3)}) \) to the sixth order can be alternatively noted as:

\[ W_1^{(4)}(\vec{H}, \vec{\rho} + \vec{\Delta \rho}^{(3)}) = W_1^{(4)}(\vec{H}, \vec{\rho} + \vec{\Delta \rho}^{(3)}) - W_1^{(4)}(\vec{H}, \vec{\rho}) + W_1^{(4)}(\vec{H}, \vec{\rho}) = \nabla W_1^{(4)}(\vec{H}, \vec{\rho}) \cdot \vec{\Delta \rho}^{(3)} + W_1^{(4)}(\vec{H}, \vec{\rho}) = W_2^{(6E)}(\vec{H}, \vec{\rho}) + W_1^{(4)}(\vec{H}, \vec{\rho}). \quad (2-11) \]

Thus, the aberration function with the pupil vector located on the exit pupil, to the sixth order is expressed as follows:

\[ W(\vec{H}, \vec{\rho}) = W_1^{(4)}(\vec{H}, \vec{\rho}) + W_1^{(6I)}(\vec{H}, \vec{\rho}) + W_2^{(4)}(\vec{H}, \vec{\rho}) + W_2^{(6I)}(\vec{H}, \vec{\rho}) + W_2^{(6E)}(\vec{H}, \vec{\rho}). \quad (2-12) \]

Figure 2-3. Scheme of an optical system consisting of two surfaces. Pupil vector is located at the exit pupil plane causing the transverse pupil aberration \( \vec{\Delta \rho} \) at the intermediate pupil plane (e.g. stop).

2.1.6 The wave aberration function in non-rotationally symmetric systems

2.1.6.1 Nodal aberration theory

In previous sections, the wave aberration function was considered under the assumption of a rotational symmetry of an optical system. However, the aberration coefficients can be also
derived for non-symmetric systems. One approach is to use the assumption proved by Buchroeder [30], that each surface generates a conventional, rotationally symmetric aberration field, centered along the local optical axis (LOA), which is a line connecting the center of the intermediate pupil with the center of curvature of the surface. Further, the aberration field in the image plane is the sum of contributions from all surfaces, referred to the optical axis ray. The optical axis ray (OAR) is a ray connecting the center of the field with the centers of all intermediate pupils. To refer aberration fields of individual surfaces to the common OAR, the vector $\vec{\sigma}$ is introduced in the image plane; see Figure 2-4.

![Figure 2-4](image)

Figure 2-4. The vector $\vec{\sigma}$ is defined for each surface to refer the individual aberration fields, centered along the local optical axis (LOA), to the common optical axis ray (OAR) in the final image plane.

Thus, the Equation (2-5) for non-symmetric systems is written as:

$$W(H, \rho) = \sum_{s=1}^{N} \sum_{j,m,n} W_{k,l,m}(H - \vec{\sigma}_s) \cdot (H - \vec{\sigma}_s)^j \cdot (\rho \cdot \hat{\rho})^m \cdot (\rho \cdot \hat{\rho})^n.$$  \hspace{1cm} (2-13)

The most important benefit, resulting from employing this form of the wave aberration function, is that by breaking the system’s axial symmetry no new aberration types are introduced. The only consequence is that all the field dependent aberration coefficients vanish in different locations in the image plane, called nodes. This nodal behavior discovered by Shack and explored by Thompson in his works [12, 31], provides valuable insights for correction of non-symmetric optical systems.
2.1.6.2 Aberration fields of plane symmetric systems

There exist another approach for describing aberrations of non-axially symmetric systems with the wave aberration function. Instead of introducing the vector \( \vec{\sigma} \) that represents the decenter of the OAR introduced by each surface, the incident angle \( I \) of the OAR at the intersection point with a given surface is accounted [11]. This introduces the field constant aberration coefficients other than spherical aberration, such as field constant coma and field constant astigmatism. By comparing coefficients of different field dependencies, nodes in the field of specified aberration type can be found. Additionally, the inclination of image and object planes with respect to the OAR is considered through the angles \( \theta \) and \( \theta' \); see Figure 2-5.

![Figure 2-5](image)

Incident angles \( I_s \), the OAR makes with each surface in a common plane of symmetry are accounted. Additionally inclinations of object and image planes with respect to the OAR is considered through angles \( \theta, \theta' \) respectively.

The vectors \( \vec{H} \) and \( \vec{\beta} \) similar as in nodal aberration theory (NAT) are defined perpendicular to the OAR, however the rotation angle with respect to the plane of incidence needs to be considered. This is realized by introducing the symmetry unit vector \( \vec{t} \). Thus, three resulting angles each vector makes with one another in the plane looking down the OAR are defined; see Figure 2-6.
This leads to additional terms in the expansion of the wave aberration function:

\[
W(\vec{H}, \vec{\rho}, \vec{i}) = \sum_{k=1}^{N} \sum_{m,n,p,q} W_{2k+n+2m+n+q,n,p,q} (\vec{H} \cdot \vec{H})^k \cdot (\vec{\rho} \cdot \vec{\rho})^m \cdot (\vec{H} \cdot \vec{\rho})^n \cdot (\vec{H} \cdot \vec{i})^p \cdot (\vec{\rho} \cdot \vec{i})^q, \quad (2-14)
\]

where \( W_{2k+n+2m+n+q,n,p,q} \) represents the coefficient of a particular aberration form defined by the integers \( k, m, n, p \) and \( q \).

In this approach the first-order properties of a system are defined with paraxial rays in a sagittal plane. The sagittal plane is not physically a plane but a set of planes oriented according to the OAR. However, optically the OAR is considered a straight line and the first-order properties of a system are defined in analogy to axially symmetric systems.

The introduction of the vector \( \vec{i} \) assumes a common plane of incidence of the OAR which limits the applicability of the approach to single plane symmetric systems. However, a general system can be treated as a concatenation of plane symmetric systems. In this case the wave aberration function is represented with respect to the multiple vectors \( \vec{i} \) defined perpendicular to the common OAR [32].

### 2.1.7 Pupil coordinates

As mentioned in Section 2.1.1, according to Gaussian model, the pupil and the field vectors are located on planes. Modeling the first-order imagery in this way assures the common set of coordinates in the field and the pupil. However, ideal wavefront with finite conjugates propagates in a spherical shape and the wave aberration function is defined as a deviation from that sphere in the exit pupil. Thus, one of the requirements for the aberration-free imagery to occur, is the fulfilment of sine condition, formulated by Abbe as:
\[ \frac{\sin U}{u} = \frac{\sin U'}{u'} \] (2-15)

where \( U \) and \( U' \) are slope angles of real rays before and after refraction, and \( u \) and \( u' \) are slopes of paraxial rays [33]. Paraxial rays are rays close to the optical axis, so the law of refraction can be approximated with the first-order term in Taylor expansion, which yields that sine function is expressed as:

\[ \sin u = u. \] (2-16)

Consequently, mapping pupil coordinates onto a plane is not compatible with modeling the fulfilment of the sine condition for real rays outside the near axis regime. Alternatively, the first-order imagery can be modeled with the pupil vector located on the pupil sphere and sampled according to the sine of the angle. Comparison of both possibilities for locating the pupil vector is shown in Figure 2-7.

In case of the Gaussian model, called also tangent ideal, transverse pupil coordinates \((\rho_x, \rho_y)\) are related to the slope angle of the first-order ray \( u \) by:

\[ \frac{|\vec{\rho}_1|}{l} = \tan u_1, \] (2-17)

where \( l \) is a distance between pupil and image planes, and \(|\vec{\rho}_1|\) is the length of the pupil vector measured in transverse coordinates. In the latter case, the point of the same transverse coordinates is placed on the pupil sphere oriented perpendicularly to the chief ray, therefore:

\[ \frac{|\vec{\rho}_2|}{R} = \sin u_2, \] (2-18)

where \( R \) is the distance between pupil and image planes and \(|\vec{\rho}_2|\) is the length of the pupil vector measured in transverse coordinates. In this way in the lack of the transverse pupil
aberrations $\Delta \rho$ the ideal imagery can be fulfilled also for real rays with large slope angles, if this occurs optical system is called isoplanatic. Choosing pupil spheres as the reference for the pupil transverse coordinates is also suitable for calculations of diffraction image theory [34].

However, mapping of an object plane onto an image plane by the way of pupil spheres introduces ambiguity that each field point is assigned a reference sphere with a different radius of curvature. This can be avoided by employing an ideal imagery model in which the field vector is also located on a sphere in object and image spaces, termed the sine ideal [35]. Lens designers are nevertheless more interested in properties of systems imaging onto plane sensor surfaces. Thus, similarly as in [28] the “hybrid” model with object and image planes and pupil spheres is selected further in this thesis.

2.2 Wave aberrations determined numerically

The wave aberration function can be also determined directly from the ray tracing data by evaluating OPL values for each ray in the exit pupil. In contrary to the analytical approach presented in the previous section, this approach does not employ any approximations. Thus, no limitations are imposed on the level of accuracy of the obtained wave aberration, except for discretization. Moreover, suitable references can be selected without complicated derivations resulting from any discrepancy from a first-order imagery model.

2.2.1 The optical path difference (OPD) formula

A wavefront is defined as a surface of equal OPL’s measured along rays originating from a single field point. In order to determine the direction of propagation, the reference ray is needed. The wavefront error is then defined as a deviation from the shape of an ideal spherical wavefront, centered along the reference ray. To evaluate the total wave aberration, first the reference sphere is constructed in the exit pupil and the OPL for each ray is determined. Further the optical path difference (OPD) with the OPL of the reference ray is calculated:
The OPD map is created based on the intersection coordinates of each ray \((\hat{p})\) at the selected pupil.

To establish a relation with the ideal imagery model, the first-order chief ray is selected as the reference ray. It intersects the image plane and the object plane at the same normalized coordinates, determined with the field vector \(\vec{H}\). Thus, the field dependency is included in each calculated OPD, and after scaling the OPD map with the wavelength, one can write:

\[
W_{tot}(\vec{H}, \hat{p}) = \frac{OPD(\hat{p})}{\lambda}. \tag{2-20}
\]

In the Gaussian imagery model a common exit pupil plane is defined and all reference spheres are located at the similar point on the optical axis. However, in real systems with a large field of view and prominent pupil aberrations, the real chief rays intersect the optical axis often in a considerable distance from the common pupil plane. Thus, in order to provide lens designer with point-imaging properties of the system, the real chief ray is selected as a reference ray and the individual locations of the exit pupil reference spheres are assigned to each field point; see Figure 2-8.

Equation (2-19) requires subtraction of two terms, each with the order of magnitude similar to the length of the optical system (typically hundreds of mm), to obtain the wavefront error, which is measured with the multiple of the wavelength. Thus, in the past formulas reducing the demand on the numerical precision were developed [3]. However, these are not necessary with the currently available numerical precision of 15 digits.
### 2.2.2 Alternative definition of surface contributions

In the Gaussian model each surface has an associated entrance and exit pupil plane centered upon the optical axis (OA). In this way the exit pupil of one surface is at the same time the entrance pupil of the subsequent surface. Thus, surface contributions are defined as the change of the wavefront resulting from refraction on the surface and propagation between the corresponding pupil planes. This overlap is however only possible to define for axially symmetric systems. As mentioned in Section 2.2.1, the real chief ray (RCR) typically intersects the optical axis in a considerable distance from the first-order chief ray intersection point, so the position of the common pupil plane cannot be unambiguously defined for all field points.

The numerical approach allows for the simple implementation of an alternative definition of surface contributions that omits the concept of intermediate pupils. Instead of dividing the system into subsystems with individual entrance and exit pupils, the separation into segments of the optical path measured along the RCR is applied. In this way the surface contribution is defined as an aberration effect of refraction on the surface of interest and the propagation distance until the subsequent surface [36]; see Figure 2-9.

![Figure 2-9](image)

**Figure 2-9.** An alternative definition of surface contributions to the total wave aberration. Instead of dividing the system into subsystems bounded by intermediate pupils (entrance pupil, stop, exit pupil) (blue color), surface contributions are defined as segments of the optical path measured along the chief ray from the surface of interest until the subsequent surface (red color).

In order to find the effect of refraction, the geometrical construction used to derive Seidel coefficients is employed; see Figure 2-10.
Thus, OPD accumulated along the real ray (RR) as a result of refraction is obtained as the deviation from the spherical wavefront:

\[
OPD_{RR} = n\overline{PB'} - n\overline{PA} = n\overline{PB'} - n\overline{PB}. \quad (2-21)
\]

The distances \(\overline{PB'}\) and \(\overline{PB}\) are directly accessible from ray-tracing data, therefore no further simplification is required. The residual OPD arising upon propagation in free space is directly obtained from Equation (2-19). The similar definition of surface contributions was presented by Gross [37].

Locating reference spheres at the surfaces, leads to ambiguity in case the surface of interest is located near a strong caustic region. However, this only concerns intermediate results. The total wave aberration is evaluated at the exit pupil reference sphere of the system as described in Section 2.2.1.

### 2.2.3 First-order ray tracing

As mentioned previously aberrations are defined as a deviation from the ideal imagery. Thus, in order to evaluate aberrations from ray-tracing data a set of references is necessary. In case of axially symmetric systems it is possible to define the first-order properties from the trace of rays close to the optical axis, termed paraxial rays. This idea can be expanded to study rays that travel in a close proximity to an arbitrary base ray, termed parabasal rays [38]. The parabasal rays serve to define references in general systems where the concept of the optical axis is replaced with the optical axis ray (OAR), introduced in Subsection 2.1.6.
2.2.3.1 Grid distortion

Distortion is the image shape aberration that describes varying magnification over the image height. As explained in Subsection 2.2.1, distortion is not taken into account if wavefront errors are defined in reference to the real chief ray (RCR). Instead distortion is analyzed separately, as a deviation from the grid of points [39]. The percentage of distortion is calculated from the difference in height between the real and the first-order chief ray in the image plane. The reference heights of the first-order chief rays are found by scaling intersection points of the parabasal field rays to respective normalized field coordinates. An anamorphic scaling for the general case of astigmatic systems is applied; see Figure 2-11.

Thus, normalized perpendicular components of the transverse aberration in the image plane (distortion) are evaluated according to the formula:

\[
\Delta H_{CRx} = \frac{|\vec{x}_{RCR}| - |\vec{x}_{ref}|}{|\vec{x}_{ref}|}, \quad \Delta H_{CRY} = \frac{|\vec{y}_{RCR}| - |\vec{y}_{ref}|}{|\vec{y}_{ref}|},
\]

(2-22)

where \(\vec{x}\) and \(\vec{y}\) are perpendicular vectors in the image plane.

For optical systems using angles of chief rays as a definition of the field, reference heights in the image plane are scaled according to tangents of the field angles.

2.2.3.2 Exit pupil shape

For systems with circular apertures in the Gaussian imagery model the shape of the exit pupil sphere is also perfectly circular. However, as mentioned in Subsection 2.2.1 in case of systems
with large FOV or tilted mirror systems, the exit pupil reference sphere is constructed upon the RCR to specify point-imaging properties more accurately. In addition to dislocation of the exit pupil sphere it is also important to consider that propagating wavefronts are astigmatic. Thus, due to both; intermediate primary astigmatism and long propagation distances, the boundary shape of the propagating set of rays changes from initially circular to elliptical in the exit pupil. To the first-order the change of boundary shape is modeled with parabasal aperture rays. Thus, two orthogonally oriented pairs of rays are traced in the tangential and sagittal plane, respectively. Intersection coordinates are then scaled to the full size of the normalized pupil and the complete cross-section is covered; see Figure 2-12.

Figure 2-12. The elliptical shape of the cross-section of the exit pupil in an unobscured mirror system. The semi-major and the semi-minor axes of the beam footprint are defined with tangential (MR\textsubscript{tan}) and sagittal (MR\textsubscript{sag}) marginal rays.

### 2.2.4 Pupil distortion – ray aiming

In the analytical approach presented in this thesis, the pupil vector is chosen to be located on the exit pupil. This selection is justified in Subsection 2.1.5 as the most physically meaningful choice. In ray-tracing programs, a ray bundle launched into the system is by default assigned to a uniform grid on the entrance pupil, forming a distorted grid on the exit pupil. However, specifications for the location and the shape of the exit pupil reference sphere allow switching the position of a uniform grid to the exit pupil. This is possible thanks to an iterative ray tracing algorithm that finds rays at the object that intersect the stop surface creating a uniform, Cartesian grid [40]. In order to numerically realize switch of the location of the pupil vector, stop surface is selected at the position of the exit pupil reference sphere; see Figure 2-13.
2.3 Decomposition of the total wave aberration into Zernike fringe coefficients

As mentioned in Subsection 2.1.3, the wave aberration function allows for the deliberate analysis of the pupil-dependent aberrations. In scalar form the pupil dependency in polar coordinates is expressed as $r^n$ and the aberration coefficients are classified according to the radial order ($n$). The mixed dependency is expressed as the cosine of an angle between two vectors ($\cos^m \phi$) and characterized with the azimuthal order ($m$). There exist a set of polynomials orthogonal over a circular pupil with the unit radius that is also described as a power series in polar coordinates, namely Zernike fringe polynomials:

$$Z_n^m(r, \phi) = R_n^m(r) \cdot \begin{cases} 
\cos(m\phi) & \text{for } m > 0 \\
\sin(m\phi) & \text{for } m < 0 \\
1 & \text{for } m = 0
\end{cases} \quad (2-23)$$

The sorting of Zernike fringe terms corresponds to the sum of radial and azimuthal orders, which corresponds to the ordering of wave aberration coefficients; see Figure 2-14.
Figure 2-14. Scalar Zernike fringe polynomials and their corresponding symmetry class, based on [41].

The analytical method for converting the field dependent wave aberration coefficients to Zernike fringe coefficients was introduced by Agurok in [42]. The direct relation is nevertheless cumbersome, because Zernike coefficients represent balanced classical aberrations. This means that lower order terms are inherently built into a Zernike coefficient of higher orders to minimize the root mean square (RMS) of the resulting aberration polynomial over the aperture. For example, classical coma ($W_{131}$) contains contributions from Zernike coma ($Z_{7/8}$) and Zernike tilt ($Z_{2/3}$), so for $m > 0$ one can write:

$$W_{131} r^3 \cos \phi = c_7(3r^3 - 2r) \cos \phi + c_2 r \cos \phi. \quad (2-24)$$

Due to mentioned similarities with wave aberration coefficients, the Zernike fringe set of polynomials together with the fitting routine is a preferred method to classify numerically acquired wavefront errors of systems with circular pupils. Optical design programs typically offer analysis tool in which Zernike coefficients are obtained from least square fitting of the total wavefront error. The OPD values for each ray are summed up to the exit pupil and are by default referred to an equidistant Cartesian grid in the entrance pupil plane. Otherwise, by employing ray aiming, reference grid can be created in the plane of the aperture stop or the exit pupil plane; see Subsection 2.2.4. The reference sphere is constructed in the exit pupil plane, along with the chief ray. If the real chief ray is selected, the field-dependent (image-shape)
aberrations are not included in the shape of the obtained wavefront error, therefore generally one can write:

\[ W_{tot}(\rho_x, \rho_y) = \Sigma_i c_i Z_i(\rho_x, \rho_y), \quad (2-25) \]

where \( i \) represents a number of coefficients used for least square fitting. In case the total wavefront error is referenced to the coordinates at the elliptical exit pupil the stretching to convert an ellipse into a unit circle is needed before fitting Zernike coefficients [43]; see Figure 2-15.

![Figure 2-15](image)

Figure 2-15. The wavefront error evaluated at the uniform grid located on elliptical exit pupil is stretched into the unit circle before fitting Zernike coefficients.

Table 2-4 represents a simplified relation between wave aberration coefficients to the sixth order and Zernike fringe coefficients, taking into account only similarities in radial and azimuthal symmetries.

Table 2-4. Simplified relations between coefficients of wave aberration function and Zernike fringe coefficients.

<table>
<thead>
<tr>
<th>Aberration name</th>
<th>Vector form</th>
<th>Scalar form in polar coordinates</th>
<th>j m n</th>
<th>Characteristic Zernike fringe coefficient</th>
</tr>
</thead>
<tbody>
<tr>
<td>Zero order</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Uniform piston</td>
<td>( W_{000} )</td>
<td>( W_{000} ) 0 0 0</td>
<td>( Z_1 ) piston</td>
<td></td>
</tr>
<tr>
<td>Second order</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Quadratic piston</td>
<td>( W_{200}(\vec{H} \cdot \vec{H}) )</td>
<td>( W_{200}H^2 ) 1 0 0</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Magnification</td>
<td>( W_{111}(\vec{H} \cdot \vec{p}) )</td>
<td>( W_{111}Hr \cos \phi ) 0 1 0</td>
<td>( Z_{2/3} ) tilt</td>
<td></td>
</tr>
<tr>
<td>Focus</td>
<td>( W_{020}(\vec{\rho} \cdot \vec{p}) )</td>
<td>( W_{020}r^2 ) 0 0 1</td>
<td>( Z_4 ) defocus</td>
<td></td>
</tr>
<tr>
<td>Fourth order</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Spherical aberration</td>
<td>( W_{040}(\vec{\rho} \cdot \vec{p})^2 )</td>
<td>( W_{040}r^4 ) 0 0 2</td>
<td>( Z_9 ) spherical aberration</td>
<td></td>
</tr>
<tr>
<td></td>
<td>Formula</td>
<td>Coefficient</td>
<td>Order</td>
<td>Description</td>
</tr>
<tr>
<td>----------------</td>
<td>-------------------------------------------------------------------------</td>
<td>-------------</td>
<td>-------</td>
<td>------------------------------</td>
</tr>
<tr>
<td>Coma</td>
<td>$W_{131}(\vec{H} \cdot \vec{\rho})(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{131}Hr^3 \cos \phi$</td>
<td>0 1 1</td>
<td>$Z_{7/8}$ coma</td>
</tr>
<tr>
<td>Astigmatism</td>
<td>$W_{222}(\vec{H} \cdot \vec{\rho})^2$</td>
<td>$W_{222}H^2r^2 \cos^2 \phi$</td>
<td>0 2 0</td>
<td>$Z_{5/6}$ astigmatism $0^\circ/45^\circ$</td>
</tr>
<tr>
<td>Field curvature</td>
<td>$W_{220}(\vec{H} \cdot \vec{\rho})(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{220}H^2r^2$</td>
<td>1 0 1</td>
<td>$Z_4$ defocus</td>
</tr>
<tr>
<td>Distortion</td>
<td>$W_{311}(\vec{H} \cdot \vec{H})(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{311}H^3r \cos \phi$</td>
<td>1 1 0</td>
<td>$Z_{2/3}$ tilt</td>
</tr>
<tr>
<td>Quartic piston</td>
<td>$W_{400}(\vec{H} \cdot \vec{H})^2$</td>
<td>$W_{400}H^4$</td>
<td>2 0 0</td>
<td>$Z_1$ piston</td>
</tr>
<tr>
<td><strong>Sixth-order field</strong></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Oblique spherical aberration (sagittal)</td>
<td>$W_{240}(\vec{H} \cdot \vec{H})(\vec{\rho} \cdot \vec{\rho})^2$</td>
<td>$W_{240}H^2r^4$</td>
<td>1 0 2</td>
<td>$Z_9$ spherical aberration</td>
</tr>
<tr>
<td>6th order field Coma</td>
<td>$W_{331}(\vec{H} \cdot \vec{H})(\vec{H} \cdot \vec{\rho})(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{331}H^3r^3 \cos \phi$</td>
<td>1 1 1</td>
<td>$Z_{7/8}$ coma</td>
</tr>
<tr>
<td>6th order field Astigmatism</td>
<td>$W_{422}(\vec{H} \cdot \vec{H})(\vec{H} \cdot \vec{\rho})^2$</td>
<td>$W_{422}H^4r^2 \cos^2 \phi$</td>
<td>1 2 0</td>
<td>$Z_{5/6}$ astigmatism $0^\circ/45^\circ$</td>
</tr>
<tr>
<td>6th order field curvature</td>
<td>$W_{420}(\vec{H} \cdot \vec{H})^2(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{420}H^4r^2$</td>
<td>2 0 1</td>
<td>$Z_4$ defocus</td>
</tr>
<tr>
<td>6th order Distortion</td>
<td>$W_{511}(\vec{H} \cdot \vec{H})^2(\vec{H} \cdot \vec{\rho})$</td>
<td>$W_{511}H^3r \cos \phi$</td>
<td>2 1 0</td>
<td>$Z_{2/3}$ tilt</td>
</tr>
<tr>
<td>Piston</td>
<td>$W_{600}(\vec{H} \cdot \vec{H})^3$</td>
<td>$W_{600}H^6$</td>
<td>3 0 0</td>
<td>$Z_1$ piston</td>
</tr>
<tr>
<td><strong>Sixth-order aperture</strong></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>6th order Spherical aberration</td>
<td>$W_{600}(\vec{\rho} \cdot \vec{\rho})^3$</td>
<td>$W_{600}r^6$</td>
<td>0 0 3</td>
<td>$Z_{16}$ secondary spherical aberration</td>
</tr>
<tr>
<td>6th order aperture Coma</td>
<td>$W_{151}(\vec{H} \cdot \vec{\rho})(\vec{\rho} \cdot \vec{\rho})^2$</td>
<td>$W_{151}Hr^5 \cos \phi$</td>
<td>0 1 2</td>
<td>$Z_{14/15}$ secondary coma</td>
</tr>
<tr>
<td>Oblique spherical aberration (tangential)</td>
<td>$W_{242}(\vec{H} \cdot \vec{\rho})^2(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{242}H^2r^4 \cos^2 \phi$</td>
<td>0 2 1</td>
<td>$Z_{12/13}$ secondary astigmatism $0^\circ/45^\circ$</td>
</tr>
<tr>
<td>Un-named</td>
<td>$W_{333}(\vec{H} \cdot \vec{\rho})^3$</td>
<td>$W_{333}H^3r^3 \cos^3 \phi$</td>
<td>0 3 0</td>
<td>$Z_{10/11}$ trefoil $0^\circ/30^\circ$</td>
</tr>
<tr>
<td><strong>Eighth-order aperture</strong></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>8th order Spherical aberration</td>
<td>$W_{680}(\vec{\rho} \cdot \vec{\rho})^4$</td>
<td>$W_{680}r^8$</td>
<td>0 0 4</td>
<td>$Z_{25}$ tertiary spherical aberration</td>
</tr>
<tr>
<td>8th order aperture Coma</td>
<td>$W_{171}(\vec{H} \cdot \vec{\rho})(\vec{\rho} \cdot \vec{\rho})^3$</td>
<td>$W_{171}Hr^7 \cos \phi$</td>
<td>0 1 3</td>
<td>$Z_{23/24}$ tertiary coma</td>
</tr>
<tr>
<td>8th order aperture Astigmatism</td>
<td>$W_{262}(\vec{H} \cdot \vec{\rho})^2(\vec{\rho} \cdot \vec{\rho})^2$</td>
<td>$W_{262}H^2r^6 \cos^2 \phi$</td>
<td>0 2 2</td>
<td>$Z_{21/22}$ tertiary astigmatism $0^\circ/45^\circ$</td>
</tr>
<tr>
<td>Un-named</td>
<td>$W_{353}(\vec{H} \cdot \vec{\rho})^2(\vec{\rho} \cdot \vec{\rho})$</td>
<td>$W_{353}H^3r^5 \cos^3 \phi$</td>
<td>0 3 1</td>
<td>$Z_{19/20}$ secondary trefoil $0^\circ/30^\circ$</td>
</tr>
<tr>
<td>Un - named</td>
<td>$W_{444}(\vec{H} \cdot \vec{\rho})^4$</td>
<td>$W_{444}H^4r^4 \cos^4 \phi$</td>
<td>0 4 0</td>
<td>$Z_{17/18}$ tetrafoil $0^\circ/22.5^\circ$</td>
</tr>
</tbody>
</table>
2.4 Freeform optics

The application of freeform elements in optical systems allows for direct correction of aberrations of higher orders. In order to utilize the potential of freeforms in the ray tracing simulations a suitable mathematical description is necessary. In the design stage this is best accomplished with globally valid polynomial sets [16] added to the basic shape:

\[ z(x, y) = Z_{\text{basic}} + \sum_j c_j Z_j(x, y). \] (2-26)

The basic shape contribution is typically described with e.g. a sphere, a conic, or a biconic. The freeform sag contribution is added to characterize the deviation from the basic shape and is the part allowing for the direct correction of higher order aberrations [18].

For sake of fast convergence of optimization process, it is beneficial to select a set of orthogonal polynomials to describe the freeform sag contribution. There exist two orthogonality types, namely sag and gradient. Thus, freeform surfaces with circular apertures are typically described with sag orthogonal Zernike fringe polynomials or gradient orthogonal Q-polynomials [44]. The Zernike fringe polynomials are also commonly used to characterize wave aberrations obtained both analytically or numerically; see Section 2.3. An accurate overview of global freeform surface descriptions is provided in [18].

After an optical system is designed and freeform elements are manufactured and measured, the imaging performance of the real system needs to be simulated. The manufactured freeform element deviates in shape from the ideal solution found in a optical design program.

\[ z_{\text{dev}}(x, y) = z_{\text{real}}(x, y) - z_{\text{ideal}}(x, y). \] (2-27)

This is due to artifacts resulting from the complex fabrication process [16]. Thus, to describe the real surface typically a large number of coefficients is necessary if a globally valid polynomial set is used [45]. Alternatively, the deviation from the ideal shape can be described using local descriptions such as lateral shifted radial basis functions (RBFs) [20]:
2.5 Tolerance sensitivity analysis

The imaging performance of a real system differs from that simulated in the optical design program. Thus, for the real system to meet specifications tolerances need to be assigned after the design stage. Tolerances are divided into two categories, namely manufacturing tolerances and assembly tolerances. Further, with respect to system parameters the first group can be divided into form and material tolerances and the later into decenter and tilt tolerances. To determine values for each tolerance it is helpful to study the sensitivity of the system to changes of these parameters. This is carried out by evaluating a change in a performance criterion $b_j$ with respect to a change of system parameter $t_k$ on surface $k$ [39]:

$$\Delta b_j(t_k) = b_j^{\text{ideal}} - b_j(\Delta t_k). \quad (2-28)$$

In this way only the effect of deviation of a single parameter is evaluated. However, during manufacturing or assembling of a real system more than one parameter are typically perturbed. Thus, to estimate the net effect the superposition of changes upon each perturbed system parameter is used. There are three possible models:

- **Statistical superposition:**
  $$\Delta b_j^{\text{statistical}} = \sqrt{\sum_k \Delta b_j(t_k)^2}$$

- **Linear superposition:**
  $$\Delta b_j^{\text{linear}} = \sum_k \Delta b_j(t_k) \quad (2-29)$$

- **Worst-case superposition:**
  $$\Delta b_j^{\text{wors case}} = \sum_k |\Delta b_j(t_k)|$$

Further, in order to consider the varying azimuthal orientation of parameters the Räntsch superposition model can be applied. This adjustment step is obtained with:

$$\Delta b_j^{\text{Räntsch}} = \sqrt{\Delta b_j^{\text{statistical}} \cdot \Delta b_j^{\text{wors case}}}. \quad (2-30)$$

The sensitivity analysis is especially useful in estimating the assembly tolerances. The surface with the most significant influence on the imaging performance can be identified and used as a compensator in the alignment process of the system.

The sensitivity analysis based on the performance of perturbed systems is computationally intensive and is carried out after the design stage. However, some insights about the “as-built”, performance of a system can be gained priori, e.g. by studying aberrations generated in the
system. In [14] three designs of an optical data storage objective with NA= 0.55 are compared to estimate the “as-built” performance; see Figure 2-16.

![Figure 2-16](image1.png)

Figure 2-16. The three possible designs of an optical data storage objective with NA= 0.55. Strained surfaces are marked with circles, based on [14].

Since there is no field considered the spherical aberration is the only one generated. Thus, Seidel contributions to the spherical aberration in each design are analyzed; see Figure 2-17.

![Figure 2-17](image2.png)

Figure 2-17. Seidel contributions to spherical aberration of three designs from Figure 2-16 [14].

It is shown that despite similar total value, magnitudes of the aberration at each surface varies. It is further concluded that the preferable solution is the one without strained surfaces, meaning without significant surface contributions. In other words the smooth distribution of aberration contributions from each surface is desired for a good “as-built” performance.

In case other aberrations need to be considered the same investigation can be conducted with Seidel sensitivity parameter [46]. This parameter is defined as the sum of squares of all Seidel contributions from each surface:

$$\omega_j = \sum_l (S_{jl})^2.$$ \hfill (2-31)

Strained surfaces are the ones with a larger value of $\omega$. The performance of the whole system can then be evaluated by:
\( \Omega = \sqrt{\frac{1}{N} \sum_{j=1}^{N} \omega_j^2}. \quad (2-32) \)

There exist other possibilities to estimate the sensitivity of the system based on its ideal performance. A detailed overview of sensitivity parameters based on fundamental optical design principles can be found in [47].
Chapter 3  Novel method for decomposition of the total wave aberration

In the design process, surface-by-surface aberration contributions are of special interest. The expansion of the wave aberration function into the field- and pupil-dependent coefficients is an analytical method used for that purpose; see Section 2.1. In the following chapter, an alternative numerical method utilizing data from the trace of multiple ray sets is described [48]. Surface contributions are divided with respect to their phenomenological origin into intrinsic, induced and transfer components. Each component is determined from a separate set of rays.

3.1 Intermediate references

As specified in the former chapter the convention chosen in this thesis is that the field vector is placed at the object plane and the pupil vector is placed at the exit pupil reference sphere defined individually for each field point. In the following section, a set of intermediate references necessary to evaluate surface aberration contributions, is defined.

3.1.1 Reference spheres

The optical system is divided into segments of the optical path measured along the real chief ray (RCR); see Subsection 2.2.2. Each segment covers one surface and a distance to a subsequent surface. Surface contributions represent the change of a wavefront that occurs due to propagation through individual segments. Thus, to evaluate surface contributions, reference spheres are established directly at the intersection of the RCR with individual surfaces; see Figure 3-1. Each segment is therefore bounded with an entrance sphere before a surface and an exit sphere before a subsequent surface.
3.1.2 Intermediate images

The reference spheres are centered upon intermediate image points. The intermediate image points are defined as points of intersection of the RCR with the intermediate image plane. In order to determine the location of intermediate image planes the parabasal aperture rays (PAR) are utilized. A small fraction of the normalized pupil coordinates is selected so that rays exhibit first-order properties (are aberration free) [38]. Since emerging wavefronts in case of tilted systems are astigmatic, orthogonally oriented pairs of rays are traced. The intersection points of perpendicular pairs of rays are projected onto the OAR, and the middle point is found. This corresponds to the location of the circle of least confusion and is a suitable choice to balance intermediate astigmatism, which is especially pronounced in tilted mirror systems. Field vector is located on the object plane oriented perpendicular to the OAR. Thus, according to the trace of parabasal field rays (PFR), intermediate image planes are also oriented perpendicular to the OAR. It is important to note that this assumption is not valid for Scheimplug systems with tilted object or image planes. Consequently, surface contributions are evaluated with respect to the aberrated vector $\vec{H}$ projected on the plane perpendicular to the OAR; see Figure 3-2.
Figure 3-2. The construction of the intermediate image planes. (a) First, parabasal aperture rays (PAR) around the optical axis ray (OAR) are traced to determine the center of the intermediate image plane. (b) Next, since parabasal field rays (PFR) are parallel to the OAR, intermediate planes are oriented perpendicular to the OAR. The location of individual field points is determined from the intersection points of real chief rays (RCR) with the intermediate image planes.

The definition of the intermediate image planes based on the trace of the OAR and corresponding parabasal rays assures convergence to the Gaussian model in case of axially symmetric systems.

### 3.2 Components of surface contributions determined from the trace of multiple ray sets

The total wavefront error is defined as the map of OPDs calculated along real rays traced to the exit pupil sphere of a system. The transverse pupil coordinates \((\rho_x, \rho_y)\) are assigned to the uniform cartesian grid \((x, y)\) on the final reference sphere. If only one set of rays is traced, the grid created on an arbitrary intermediate reference sphere is distorted, which is indicated with primed coordinates \((x', y')\). This is solved by tracing multiple sets of rays aimed at the uniform
grids \((x, y)\) of local coordinates on each reference sphere. Consequently, instead of measuring the OPD along a single real ray up to the exit pupil sphere, multiple rays are used. This can be thought of as evaluating wavefront errors after each surface at the similar undistorted set of coordinates on reference spheres. Thus, wavefront errors can be subtracted from each other to find the change caused by a particular segment of a system. This is explained for the single OPD value in Figure 3-3.

![Figure 3-3. The complete surface contributions to the total OPD determined from the trace of multiple real rays (RR2 and RR4). The first-order ray (FR) coincides with RR2 at the exit pupil of the first segment and with RR4 at the exit pupil of the complete system.](image)

The contribution of the first surface is defined as the OPD at point \(B\). The contribution of the second surface is found from the difference between the OPD at points \(D\) and \(B\) on similar transverse coordinates on the entrance and the exit reference sphere of the segment

\[
OPD_{S_2} = OPD_D - OPD_B. \tag{3-1}
\]

Additivity is therefore preserved, since the sum of both surface contributions is equivalent to the total OPD calculated at point \(D\) along a single ray:

\[
OPD_{\text{total}} = OPD_{S_1} + OPD_{S_2} = OPD_D. \tag{3-2}
\]

There is no real ray intersecting points \(B\) and \(D\). One can imagine a first-order ray (FR) connecting uniform coordinates on all reference spheres.

The advantage of utilizing multiple ray sets is that the transverse pupil aberration \(-|\Delta \rho|\), which negative sign is due to the difference with the analytical approach (see Subsection 3.3), is incorporated in the contribution of the second surface.
\[-\Delta \hat{\rho} = [(B'_{x} - B_{x}), (B'_{y} - B_{y})].\]  

(3-3)

This allows for extraction of the induced effect defined here as a result of incoming aberrations and the pupil distortion. Thus, the surface contribution is further divided into the intrinsic and induced parts resulting from refraction on the surface and the transfer component, which is present due to the propagation of the aberrated wavefront in free space.

In case of the first segment of the system, the entering wavefront is ideal. Since there are no incoming aberrations, the pupil distortion is of no effect. The refraction on the surface is of purely intrinsic type. It is therefore enough to trace one ray to point A at the uniform grid \((x, y)\) of the exit reference sphere located on the first surface; see Figure 3-4.

![Figure 3-4](image)

Figure 3-4. The first real ray (RR1) is traced to determine the component of the total OPD resulting from the refraction on the first surface.

To determine the transfer component the second ray is traced to the uniform grid at the second surface entrance sphere; see Figure 3-5.
Figure 3-5. The second real ray (RR2) is traced to determine the transfer component of the total OPD resulting from propagation between surfaces.

The transfer part \( \text{OPD}_{T1} \) is then found by subtracting the OPD at point \( A \) from the OPD at point \( B \):

\[
\text{OPD}_{T1} = \text{OPD}_B - \text{OPD}_A.
\]

Defining the transfer component in this way takes into account the transverse pupil aberration measured at the reference sphere between points \( A' \) and \( A \). Thus, the transfer component is a combined effect of the pupil distortion caused by incoming aberrations of the first surface and deformation arising upon propagation of the aberrated wavefront between surfaces. Since the propagation of an ideal wavefront in free space only changes the scaling without introducing any aberration, the transfer component is considered as the part of the induced effect. This is different than in the classical division according to individual pupils of the surfaces. In that case the transfer term is not distinguished and divided between intrinsic and induced parts of successive surfaces [28]. The advantage of separating the transfer component is that it directly refers to the design parameter of the system.

The OPD contribution from the first surface is then determined by summing up the transfer and refraction parts.

The complete effect of refraction of the incoming aberrated wavefront on the second surface \( \text{OPD}_{R2} \) is found by subtracting the contribution of the first surface from the OPD at point \( C \) at the exit reference sphere located on the second surface:

\[
\text{OPD}_{R2} = \text{OPD}_C - \text{OPD}_B.
\]

This is illustrated in Figure 3-6.
The transfer component to the exit pupil of the system is found from the trace of the fourth ray in analogy to the transfer part of the first surface contribution; see Figure 3-8. The OPD along the fourth real ray is at the same time the total OPD introduced by the system evaluated at the uniform grid on the exit pupil reference sphere \((\rho_x, \rho_y)\).

In order to evaluate the effect of refraction on the second surface independently from the rest of the system, the intrinsic component is introduced. The intrinsic part is a deformation of an ideal wavefront after refraction on the surface. Consequently, to determine the intrinsic OPD, an additional ray has to be traced until point \(C\). This is realized by ignoring the first surface and tracing ray directly from the intermediate image location \((O')\); see Figure 3-8.
The fifth real ray (RR5) is traced to determine the intrinsic component of the total OPD resulting from refraction of an ideal wavefront on the second surface.

The induced part from the refraction on the second surface is found by subtracting the intrinsic component from the complete effect of refraction. It therefore evaluates the wavefront change due to the effect of incoming aberrations and pupil distortion:

$$OPD_{R2}^{ind} = OPD_{R2} - OPD_{R2}^{int}. \quad (3-6)$$

Thus, in order to determine all components of surface contributions in a system, with two surfaces and a remote exit pupil, the trace of five ray sets is necessary. The first four ray sets are traced through the complete system with the uniform grids located on the respective reference spheres. The last ray set is traced from the intermediate image location through the second surface.

3.2.1 Boundary shape of reference spheres

Since emerging wavefronts are in general case astigmatic, the boundary shape of the beam footprint at each reference sphere is elliptical. As described in Subsection 2.2.3.2, the chosen convention is that the shape of the cross-section of the wavefront entering the system is circular and changes to elliptical in the exit pupil. The semi-major and semi-minor axes of an ellipse are determined by tracing parbasal aperture rays in tangential and sagittal planes. Intersection coordinates are then scaled to cover the complete cross-section; see Figure 3-9.
The wavefront error is determined on the elliptical footprint at reference spheres assigned to each surface up to the exit pupil. The reference spheres are defined upon the real chief ray (RCR). The semi-major and semi-minor axes of the beam footprint are defined with orthogonally oriented marginal rays \((MR_x, MR_y)\). The change of footprint shape is the induced effect resulting from primary astigmatism and propagation distances. Thus, wavefront errors are evaluated from multiple ray sets aimed at the uniform grids placed on reference spheres with elliptical boundary shapes. However, the last ray set is traced to evaluate the intrinsic component, which is independent of incoming aberration effects. Thus, rays originating from intermediate object point (see Figure 3-7) are aimed at the reference spheres with circular boundary shapes. Radii are defined, so the circles have the same area as corresponding elliptical footprints of the aberrated wavefront; see Figure 3-10.

Figure 3-9. The wavefront error is determined on the elliptical footprint at reference spheres assigned to each surface up to the exit pupil. The reference spheres are defined upon the real chief ray (RCR). The semi-major and semi-minor axes of the beam footprint are defined with orthogonally oriented marginal rays \((MR_x, MR_y)\).

Figure 3-10. The radius of the circular boundary of an ideal wavefront at a reference sphere to determine the intrinsic component is selected so the area of the circle is the same as the area of the elliptical footprint marked by an aberrated wavefront.
3.2.2 Zernike surface contributions

Zernike fringe is the set of polynomials used to classify numerically obtained wavefront errors. The wavefront errors are stretched to the shape of the unit circle and a fitting routine is applied; see Section 2.3. Thus, the total wave aberration can be written as:

\[ W_{\text{tot}}(\rho_x, \rho_y) = \sum_s \sum_i c_{is}^{\text{comp}} Z_i(\rho_x, \rho_y) = \sum_s \sum_i \left( c_{is}^{\text{int}} Z_i(\rho_x, \rho_y) + c_{is}^{\text{ind}} Z_i(\rho_x, \rho_y) + c_{is}^{\text{trans}} Z_i(\rho_x, \rho_y) \right). \]  (3-7)

Where \( c_{is}^{\text{comp}} \) is a Zernike fringe coefficient \( i \) corresponding to a contribution form surface \( s \), and \( c_{is}^{\text{int}} \), \( c_{is}^{\text{ind}} \) and \( c_{is}^{\text{trans}} \) are Zernike fringe coefficients of, intrinsic, induced and transfer components respectively.

The bar plots obtained from the program implemented in Matlab® illustrate Zernike aberration components to the total wave aberration of an arbitrary three mirror system; see Figure 3-11. Zernike aberrations of a system are presented either with respect to a surface \( s \) or as surface contributions of a selected Zernike fringe coefficient \( i \).

![Figure 3-11](image)

Figure 3-11. The bar plots generated in Matlab®. Each set of bars represents Zernike contributions from a selected surface (\( W_{\text{comp}} \)) and is further decomposed into intrinsic (\( W_{\text{int}} \)), induced (\( W_{\text{ind}} \)) and transfer (\( W_{\text{trans}} \)) components. (a) All Zernike fringe coefficients from the contribution of a selected surface. Coefficients characteristic for wave aberration up to the fourth order (1-9) and above the fourth order (10-16) are shown with different scales. (b) Surface-by-surface contributions of a selected Zernike aberration (trefoil). The last bar set shows the components of the aberration in the exit pupil.

3.3 Comparison with analytical results

In the following section results obtained with the proposed method are compared with the wavefront error maps generated from aberration coefficients, calculated with the macro of Sasian [25]. For that purpose an axially symmetric, two-mirror system represented
schematically in Figure 3-12 is investigated. Since the stop is located at the second surface, the exit pupil of the first surface contribution is located directly before the second mirror. Thus, two divisions of the total wave aberration introduced in Subsection 2.2.2 are equivalent. For sake of comparison, the exit pupil spheres are constructed upon the first-order chief ray (FCR). Thus, aberrations due to the displacement of the field vector $\Delta \vec{H}$ are present in the evaluated wavefront errors.

![Figure 3-12](image)

Figure 3-12. The two-mirror system with the stop located at the second surface (M2). The exit pupil of the first surface contribution ($\text{ExP1}$) is located directly before the second mirror. The exit pupil of the second surface contribution is sequenced directly after the second mirror ($\text{ExP2}$). Thus, aberrations of the second surface are exclusively the result of the reflection from the second mirror. The reference spheres are centered upon the first-order chief ray (FCR).

The comparison of results obtained with both methods shows that the distribution of surface contributions is changed; see Figure 3-13. This is due to the difference in the location of the pupil vector. All wave aberration coefficients are evaluated for the pupil vector $\vec{\rho}$ located on the exit pupil plane of the system, whereas in the numerical approach OPDs are referred at the uniform grids on the exit pupil spheres of the respective surfaces. It means that in case of the first surface, the contribution is referred to the exit pupil of the first mirror which corresponds to the distorted vector $\vec{\rho} + \Delta \vec{\rho}$ on the pupil of the systems. Thus, the redistribution of surface contributions is due to two factors; the use of pupil spheres instead of planes and the change in the location of the pupil vector from the exit pupil to the intermediate exit pupils assigned to each surface.
Figure 3.13. The comparison of wavefront error maps evaluated from the wave aberration coefficients and obtained with the proposed numerical method (a) contribution from the first surface according to the aberration coefficients, (b) the difference between analytical and numerical results, (c) contribution from the second surface according to the aberration coefficients, (d) the difference between analytical and numerical results, (e) the total wave aberration according to the aberration coefficients, (f) the residual difference between analytical and numerical total wavefront errors.

However, it is important to emphasize that in case of the total wave aberration the pupil vector is still placed on the exit pupil reference sphere of the complete system. This is due to the concatenation of the intermediate exit pupils; see Equation (3-2). Thus, the difference in the
total wave aberration is only due to the change in the pupil shape, which is of less significance as shown in Figure 3-13(f).

The redistribution of the surface contributions due to the different position of the equidistant pupil grid, results in the sign difference of the induced component. As described in Subsection 2.1.5, in [29] the induced part of the second surface up to the sixth order depends on the fourth-order incoming aberrations and the third-order transverse pupil aberration of the first surface, measured with respect to the exit pupil of the system; see Equation (2-9).

Analogously, in case of the example system, for the numerical approach the induced part of the second surface contribution with no restriction to the expansion order can be noted by:

\[
W_2^{(\text{ind})}(\vec{H}, \rho) = \left(W_{\text{tot}}(\vec{H}, \rho) - W_1(\vec{H}, \rho + \Delta \rho)\right) - W_2^{(\text{int})}(\vec{H}, \rho). \quad (3-8)
\]

The term in the parenthesis is the complete contribution of the second surface defined as in the Equation (3-1). The transverse pupil aberration is included with a different subtraction order than in Equation (2-9). The same sign difference was indicated while deriving the transverse pupil aberration in Equation (3-3). The further difference between both induced parts is due to the transverse pupil aberration evaluated numerically on a sphere and analytically on a plane; see Figure 3-14.
3.4 Full field analysis

3.4.1 Full field displays

An aberration of the specific kind can be analyzed simultaneously for all field points using a graphic representation called full-field display (FFD). The FFD representation was introduced as an analysis tool for nodal aberration theory (NAT) to track locations of nodes in aberration fields [12]. In [23] Fuerschbach et al. used FFDs as a representation for numerically obtained Zernike aberration coefficients. The same approach is employed to analyze Zernike surface contributions over the full field of view (FOV).

According to the Table 2-4 each pupil-dependent non-rotationally symmetric aberration is characterized by two Zernike fringe coefficients. Thus, up to the sixth order five pairs are distinguished; Zernike astigmatism, Zernike coma, trefoil, Zernike secondary astigmatism, Zernike secondary coma. The rotationally symmetric aberrations are characterized by only one term. These are; Zernike spherical aberration and Zernike secondary spherical aberration. Each Zernike aberration is represented graphically by one of four types of symbols; see Figure 3-15.

Figure 3-14. The comparison of the induced components from the second (a) the induced sixth-order term, (b) the induced component obtained numerically.
In order to define the magnitude and the orientation of a non-rotationally symmetric Zernike aberration, following formulas are used [23]:

\[
|Z_{i/i+1}| = \sqrt{Z_i^2 + Z_{i+1}^2} \quad (3-9)
\]

\[
\theta_{i/i+1} = \frac{1}{2} \tan^{-1}\left(\frac{Z_{i+1}}{Z_i}\right). \quad (3-10)
\]

The FFD can be used in two different ways to analyze an aberration field of an arbitrary system; see Figure 3-16. The first is to consider the complete contributions from respective surfaces. The second is to examine the total wave aberration in the exit pupil with distinction into components.
As presented, depending on which Zernike aberration is studied, different configurations of the FFD are more suitable. For Zernike coma, insights are provided by looking at the complete surface contributions, whereas correction of Zernike secondary coma results from the balance between induced, intrinsic, and transfer components.

### 3.4.2 Distortion grid

As described in subsection 3.1.2, intermediate image planes are necessary to determine the center of curvature of reference spheres. Thus, in analogy to subsection 2.2.3.1, an intermediate grid distortion can be evaluated in terms of perpendicular components of the normalized field
vector; see Equation (2-20). Further it is possible to define surface contributions as the effect on the final grid introduced by each surface of the system; see Figure 3-17.

However, it is important to note that the distortion surface contribution is then evaluated with respect to the plane perpendicular to the OAR, which is not necessarily the case for the final image plane. In case the intermediate image plane is at infinity the contribution from the surface is not evaluated. Thus, surface contributions to the distortion of the final image grid \( \Delta \vec{H}_{Sj} \) for the system in Figure 3-17 are given as:

\[
\Delta \vec{H}_{S1} = \Delta \vec{H}_A,
\]

\[
\Delta \vec{H}_{S2} = 0,
\]

\[
\Delta \vec{H}_{S3} = \Delta \vec{H}_B - \Delta \vec{H}_A.
\]

### 3.5 Implementation

The described method is implemented in Matlab® 32bit. Ray-tracing data is imported from Zemax13® to Matlab® workspace utilizing DDE protocol. After first establishing DDE connection initial system data is read into Matlab®. The initial system is then automatically modified. Next, multiple sets of rays are iteratively traced through the modified system. Ray-tracing data is transferred to Matlab® workspace after each iteration; see Figure 3-18. It is a part responsible for the relatively long computational time; see Appendix A. In the final stage
components of the total wave aberration are evaluated in Matlab® following the routine described in Section 3.2.

![Diagram](image)

Figure 3-18. The flow of data between Matlab® and Zemax®. Both programs communicate through DDE protocol.

### 3.5.1 User-defined parameters

Before establishing the DDE connection with Zemax®, the user is asked to specify parameters necessary to perform the trace of multiple ray sets. These parameters are:

- Sampling
- Parabasal parameter
- Selection of infinity ray path.

Sampling ($nP$) is a discretization parameter that specifies how many rays are traced along each perpendicular axis of the circular ray bundle launched into the system; see Figure 3-19.

![Diagram](image)

Figure 3-19. The sampling number of discretization points along an axis of circular ray bundle launched into the system ($nP$).

The discretization step ($dp$) in the pupil coordinates is then determined from the formula:
\[ dp = \frac{2}{Np-1}. \quad (3-12) \]

Depending on if \((nP)\) is an even or an odd number, the center of the pupil is located at points \(\left(\frac{Np}{2} - 1, \frac{Np}{2} - 1\right)\) or \(\left(\frac{Np}{2}, \frac{Np}{2}\right)\) respectively.

The parabasal parameter defines the fraction of normalized pupil or field coordinates used for the trace of rays near the OAR, which are considered as un-aberrated. Thus, parabasal parameter strongly depends on the \(F\#\) of the system as well as on the level of correction. Ray tracing data of parabasal rays serves then to define the first-order properties of the system; see Subsection 2.2.3.

The beam path between surfaces can be specified by the intended first-order properties of the system. Thus, the user can select surfaces between which the beam is assumed to be collimated and the plane reference surfaces are assigned. If no surface is selected program utilizes an internally defined parameter. The parameter is based on the trace of the parabasal aperture rays (PAR):

\[ \varepsilon = \sqrt{(\alpha_{OAR} - \alpha_{PAR})^2(\beta_{OAR} - \beta_{PAR})^2(\gamma_{OAR} - \gamma_{PAR})^2}, \quad (3-13) \]

where \(\alpha\), \(\beta\) and \(\gamma\) are direction cosines after each surface.

If \(\varepsilon\) is below the threshold value, the program assigns the reference plane instead of the reference sphere after a surface.

### 3.5.2 Modification of the system

First, initial system data, such as number and type of surfaces and refractive indices, is read into the Matlab® workspace and structures for storing ray-tracing data are created. Afterwards, the OAR and the corresponding parabasal aperture rays are traced through the initial system in order to determine the location of the intermediate image planes. In the following step, the RCR of the field point under analysis is traced to evaluate the radii of curvature of reference spheres; see Subsection 3.1.2. Next, after saving a copy of the initial file, dummy surfaces and coordinate breaks are inserted before and after each optical surface in the lens data editor (LDE); see Figure 3-20.
In the next stage, the RCR is traced repetitively to establish reference spheres at dummy surfaces; see Figure 3-21. First, the tilt and decenter are determined from the local coordinates of the RCR at the plane dummy surface. Then, the tilt and decenter are set at the coordinate breaks before and after the reference sphere by refreshing the LDE. Second, the shift is determined from the distance between the tilted and decentered dummy surface and the optical surface. This distance is accounted along the RCR, therefore the shift is applied at coordinate breaks directly before and after a surface. In the third step, after updating the LDE, the formerly evaluated radii of curvatures are set.
Figure 3-21. The RCR is traced repetitively, updating the LDE after each time; (a) dummy surfaces inserted in the LDE before and after a surface, (b) the tilted and decentered dummy surfaces, (c) the entrance and exit reference spheres placed at the intersection points of RCR with a surface.

Lastly, the semi-major axes of ellipses (see Subsection 3.2.1) are selected as semi-diameters of the established reference surfaces. The elliptical footprints are then determined by tracing rays to the maximum normalized pupil coordinates \((1, \frac{b}{a})\) or \((\frac{b}{a}, 1)\) depending on the orientation of the semi-major axis.

### 3.5.3 Tracing multiple ray sets

As mentioned in Subsection 3.2, in order to determine components of the total wave aberration trace of multiple ray sets is required. This is realized by setting the system aperture to the “float by stop” type and selecting ray aiming. The first is to define the boundary of the ray set entering the system to be limited by the size of the stop surface. The latter ensures that each ray intersects the stop surface at the uniform grid. The stop position is then switched to the previously established reference spheres, before and after each optical surface \((j\text{Stop})\). Next, ray sets are iteratively traced to each reference sphere and each surface \((j\text{Surf})\) in order to determine segments of the OPD; see Subsection 2.2.2. The loop is executed until the current stop surface \((j\text{Stop})\) is positioned at the exit pupil reference sphere \((n\text{Stop})\); see Figure 3-22.
Figure 3-22. The trace of multiple ray sets realized by iterative switching the stop position to each reference sphere. An additional loop is necessary to determine intersection coordinates of a ray set with each surface until the current stop.

Ray-tracing data is then processed and the complete effect of refraction on each surface and the transfer components are evaluated; see Section 3.2.

In order to determine intrinsic components, surfaces in the LDE are ignored leaving only a single optical surface active. Intermediate field points are then set, creating a separate subsystem for each surface; see Figure 3-23. Ray tracing is performed for each subsystem with rays aimed at the uniform coordinates on exit reference spheres assigned to each surface.

Figure 3-23. (a) An initial system. (b-d) Subsystems created iteratively to determine intrinsic components from each surface.
The induced component is then evaluated by subtracting the intrinsic part from the complete effect of refraction; see Section 3.2.

3.5.4 Special aspects

3.5.4.1 Propagation to the exit pupil

In Zemax®, aberrations arising upon propagation to the exit pupil are added by first tracing the ray set to the image plane and then back to the exit pupil sphere [40]. In the implemented routine, the exit pupil is inserted as a surface directly after the last reference surface in the LDE; see Figure 3-24. Thus, the transfer term is evaluated from sequential ray-tracing data.

Figure 3-24. A screenshot from LDE in Zemax13® illustrating exit pupil implemented as a dummy surface placed at the end of the system.

In case the RCR does not intersect the OAR in the image plane, the plane reference surface is inserted. The distance between the exit pupil and the last surface in that case is selected to be equal to ten times the focal length of a system.

3.5.4.2 Vignetting

In case a ray launched to the system does not intersect with one of the surfaces, the vignetting occurs. This situation is critical since the introduced method is based on the assumption that all rays pass through the complete system, creating uniform grids at the stop surface iteratively switched to each reference sphere. Consequently, if vignetting is detected the aperture of the system needs to be decreased to the level that allows all rays to be traced. This would be better
realized with a simultaneous switch of the RCR to the central ray of the vignetted ray bundle. However, it cannot be performed with the DDE protocol. Thus, the aperture is decreased more than necessary; see Figure 3-25.

Figure 3-25. The routine cannot be executed if vignetting occurs; (a) the initial ray bundle, (b) the ray bundle reduced to the maximum extent that traverses the complete system centered around the same RCR.

Numerically there exist two types of vignetting. In the first case, the diameter of a surface defined by the user is too small for all rays to pass through the system, but all rays traverse the system if diameters are of the automatic type. In the second case, the aperture defined by the user is too large for all rays to pass through due to geometrical limitations of the system, e.g. total internal reflection. Since the routine is based on shifting the stop position, this situation is critical for the execution of the program. If the stop position is shifted to the reference sphere after vignetted surface, the ray set defined by the size of the stop cannot be launched into the system and Zemax returns an error. Consequently, the presented approach is only valid for the first type of vignetting.

3.5.4.3 Position of the entrance pupil

In optical design programs, in order to refer to a specific ray launched into a system, the normalized entrance pupil coordinates are used. This is independent of ray aiming. Consequently, while switching the position of the stop (see Subsection 3.5.3), the location of the entrance pupil is changed correspondingly. In case location of the entrance pupil in reference to the object plane is changed, the same normalized pupil coordinates refer to a different ray; see Figure 3-26. Since wavefront errors obtained for different positions of the stop are compared, this aspect needs to be considered in the implemented routine.
Figure 3-26. The marginal ray (MR) defined in two possible cases of locating the entrance pupil in reference to the object plane; (a) case in which the entrance pupil is located after the object plane, (b) case in which entrance pupil is located before the object plane.
Chapter 4  Application

In the design process of a freeform system, it is important to utilize additional design variables in the most effective way [21]. The simple approach of adding freeform sag contribution to one or more elements in the system may result in an “over-engineered” solution with an unnecessarily large deviation of sag from the basic shape; see Section 2.4. Thus, analysis of aberrations generated in the system utilizing the same description (Zernike fringe set) as the one used for the freeform sag, is a valuable tool in designing freeform systems. In the following chapter, it is presented how analysis of the Zernike surface contributions can assist in selecting the most effective first-order configuration and a position of the freeform element in the system.

4.1 Relations between low- and higher-order Zernike aberrations

Imaging performance of freeform mirror systems in the final design stage is typically limited by higher-order Zernike aberrations. Thus, the knowledge of how higher-order aberrations are generated is of crucial importance in the design process of such systems. As known from aberration theory of axially symmetric systems, the higher-order aberration coefficients depend on primary aberrations and the first-order ray properties; see Subsection 2.1.5. General dependencies that occur in formulas for the sixth-order intrinsic wave aberration coefficients (see Table 2-3) can provide valuable insights for the interpretation of numerically obtained Zernike terms. Thus, taking into account these relations, following dependencies are formulated for the intrinsic Zernike aberration components of a single field point:
Table 4-1. Dependencies of the higher-order intrinsic Zernike components on low-order Zernike aberrations.

<table>
<thead>
<tr>
<th>Zernike intrinsic components</th>
<th>Zernike coefficients</th>
<th>Influencing factors</th>
</tr>
</thead>
<tbody>
<tr>
<td>Zernike sixth-order spherical aberration</td>
<td>$Z_{16}^{int}$</td>
<td>$Z_9, u'$</td>
</tr>
<tr>
<td>Zernike secondary coma</td>
<td>$Z_{14/15}^{int}$</td>
<td>$Z_{7/8}, u'$</td>
</tr>
<tr>
<td>Zernike secondary astigmatism</td>
<td>$Z_{12/13}^{int}$</td>
<td>$Z_{5/6} - Z_{7/8}, u'$</td>
</tr>
<tr>
<td>Zernike trefoil</td>
<td>$Z_{10/11}^{int}$</td>
<td>$Z_{5/6}, u'$</td>
</tr>
</tbody>
</table>

where $u'$ is a slope of an outgoing marginal ray.

In analogy, the induced and transfer Zernike components depend on accumulated low-order aberrations and the first-order ray properties. However, due to crucial differences in the definition of the induced effect (see Section 3.3), aberration theory of axially-symmetric systems provides little insights for interpretation of the induced and transfer Zernike components.

By employing mentioned aberration relations, the design strategy based on assessing the potential of a studied system for the simultaneous correction of low- and higher-order Zernike aberrations is formulated. In this approach the effect of adding a low-order Zernike-type freeform is analyzed. Dominant primary Zernike aberrations are directly corrected by the freeform sag contribution and higher-order Zernike components are influenced due to relations listed in Table 4-1. Further, Zernike aberrations in a system with and without a freeform are compared and the most beneficial first-order configuration or position of the freeform element in a system is selected.

4.2 Selection of the initial system

In the following section, it is demonstrated how the analysis of surface-by-surface Zernike aberration contributions supports the optimization process in finding the best geometry for a freeform mirror system.
4.2.1 Geometry of the system

The investigated system is a three-mirror anastigmat (TMA) with small FOV, an $F\#$ of 2.4 and an entrance pupil diameter of 40 mm.

In the first step obscured initial systems are considered in two configurations; with the negative element placed at the position of the first (NPP) and the second mirror (PNP); see Figure 4-1. The NPP configuration is based on the system investigated in [15]. The PNP is the reflective analogue of Cooke triplet, which is a solution that has been extensively investigated since early years of the TMA development [50]. The PNP configuration is much more compact with approximately four times smaller diameter of the beam at the second mirror. Both configurations are optimized for a central field point.

![Figure 4-1. The obscured, on-axis initial systems; (a) with the negative element at the first mirror NPP, (b) with the negative element at the second mirror PNP](image)

In the next step, in order to avoid central obscuration, tilt angles are applied. Two cases with the so-called “zigzag” and folded geometry are studied. The resulting four layouts, with optimized tilt angles, are demonstrated in Figure 4-2. Both resulting PNP systems are much smaller in size in comparison to their NPP equivalents. It is also noticed, that for given configuration arranging mirrors in the folded geometry reduces the volume of the system. On the other hand, tilt angles applied in the “zigzag” geometry are typically smaller. Another difference between the “zigzag” and folded geometries is the sign of the tilt angle applied to the second mirror.
Further, radii of curvatures in all systems are reoptimized for the smallest spot size RMS values with the low-order Zernike-type surface placed at the position of the last mirror. Due to the plane symmetry of the TMAs, only Zernike terms 5, 8 and 9 are used to describe the freeform sag contributions.

4.2.2 Zernike surface contributions analysis

The freeform sag contribution added to the last mirror changes the distribution of dominant aberrations of the TMA, namely primary Zernike astigmatism and coma so that contributions from first two mirrors are compensated. However, in case of higher-order aberrations, the impact on final correction is limited mainly to the change of the intrinsic component from the last mirror. The induced and the transfer terms from the last mirror are not significantly affected. Thus, Zernike trefoil and in some configurations also Zernike secondary astigmatism arise as performance limiting aberrations.

The potential for simultaneous correction of low- and higher-order Zernike aberrations of each configuration is assessed. The Zernike surface contributions in systems consisting of basic-shape mirrors and then after adding the freeform sag contributions are compared for the central field point. The compensation effect of Zernike astigmatism ($Z_5$) and Zernike coma ($Z_8$) is presented in bar plots. Further, the balancing effect of the intrinsic, induced and transfer...
components of Zernike trefoil ($Z_{11}$) and Zernike secondary astigmatism ($Z_{12}$) is studied in each configuration.

In case of the “zigzag” TMA with the negative element as the first mirror (NPP), the impact of the freeform sag is mainly to invert the Zernike astigmatism contribution from the last mirror in order to compensate the negative contribution from the second mirror; see Figure 4-3.

![Figure 4-3](image)

Figure 4-3. The Zernike aberrations of the NPP “zigzag” configuration. (a) Zernike astigmatism ($Z_5$) and Zernike coma ($Z_8$) in the system without the freeform sag contribution, (b) trefoil ($Z_{11}$) and Zernike secondary astigmatism ($Z_{12}$) in the system without the freeform sag contribution, (c) Zernike astigmatism ($Z_5$) and Zernike coma ($Z_8$) in the system with the freeform sag contribution, (d) trefoil ($Z_{11}$) and Zernike secondary astigmatism ($Z_{12}$) in the system with the freeform sag contribution.

The higher-order Zernike components are generated mostly at the last surface due to large slope of the outgoing marginal ray. In analogy to Zernike astigmatism, adding the freeform sag results in inverting the intrinsic component of Zernike trefoil, which balances the in this case unaffected induced part. Further, the freeform element reduces Zernike coma, which is of the same sign as Zernike astigmatism. Consequently, intrinsic Zernike secondary astigmatism is diminished. The resulting freeform system is strained due to large aberration contributions but well corrected for the low- and the higher-order aberrations simultaneously.
As next the folded TMA with the negative element at the first mirror (NPP) is studied; see Figure 4-4. It is noticed that in comparison to the “zigzag” geometry, the overall amount of generated astigmatism is significantly reduced due to smaller tilt angles at the second mirror. Similarly, the higher-order Zernike components are generated in particular at the last surface and the sign of astigmatism from the last surface has to be inverted. Consequently, the resulting positive intrinsic component of Zernike trefoil balances well the residual negative terms. Zernike secondary astigmatism is canceled at the last mirror due to the reduction of primary Zernike coma. Thus, the imaging performance is limited due to the contribution to Zernike secondary astigmatism from the second mirror.

![Graphs showing Zernike aberrations with and without freeform sag contribution.](image)

Figure 4-4. Zernike aberrations of the NPP folded configuration. (a) Zernike astigmatism (Z5) and Zernike coma (Z8) without the freeform, (b) trefoil (Z11) and Zernike secondary astigmatism (Z12) without the freeform, (c) Zernike astigmatism (Z5) and Zernike coma (Z8) with the freeform, (d) trefoil (Z11) and Zernike secondary astigmatism (Z12) in the system with freeform.

The third studied configuration is the “zigzag” TMA with the negative element at the second mirror (PNP); see Figure 4-5. The approximately four times smaller beam diameter at the second mirror, in comparison to the NPP configurations, leads to near lack of the coma.
contribution from the second mirror. In this system, the freeform element slightly increases Zernike astigmatism at the last mirror and inverts the Zernike coma contribution. Consequently, primary aberrations of the same sign cancel out Zernike secondary astigmatism from the third surface and the correction in the image plane is obtained. Further, it is noticed that the correction of Zernike trefoil is obtained due to the increase of the induced component at the third mirror. This suggests that the minor freeform sag contribution is “tailored” for the incoming aberrated wavefront and the intrinsic component remains nearly unchanged.

Figure 4-5. Zernike aberrations of the PNP “zigzag” configuration. (a) Zernike astigmatism (Z5) and Zernike coma (Z8) without the freeform, (b) trefoil (Z11) and Zernike secondary astigmatism (Z12) without the freeform, (c) Zernike astigmatism (Z5) and Zernike coma (Z8) with the freeform, (d) trefoil (Z11) and Zernike secondary astigmatism (Z12) in the system with freeform.

The last considered configuration is the folded TMA with the negative element at the second mirror (PNP); see Figure 4-6. Similarly as in the “zigzag” PNP configuration, only minor reduction of astigmatism and the inversion of the coma from the last mirror are required. This results in deteriorated performance in terms of the higher-order Zernike terms. Zernike secondary astigmatism from the third mirror is diminished and the residual contribution in the exit pupil increases. Same applies in case of trefoil. Further, it is noticed that the opposite tilt
angle of the second mirror leads to an inverted relation between the induced and intrinsic components of trefoil at the second mirror.

![Figure 4-6. Zernike aberrations of the PNP folded configuration. (a) Zernike astigmatism (Z5) and Zernike coma (Z8) without the freeform, (b) trefoil (Z11) and Zernike secondary astigmatism (Z12) without the freeform, (c) Zernike astigmatism (Z5) and Zernike coma (Z8) with the freeform, (d) trefoil (Z11) and Zernike secondary astigmatism (Z12) in the system with the freeform.](image)

In the next step two configurations with the highest potential for simultaneous correction of low- and higher-order Zernike aberrations are down selected for further investigation with two freeform surfaces. The NPP “zigzag” is well corrected in the exit pupil but is the most strained, which make it inadvisable selection for a further design development. In case of the PNP folded system, the correction of primary aberrations leads to the imbalance of the higher-order terms in the exit pupil. Thus, the PNP “zigzag” and the NPP folded configurations are chosen. Indeed these are the layouts most commonly found in the literature and patents [15, 50].

The two systems are reoptimized with the second freeform sag contribution added to the stop at the second mirror and the FOV of 1 deg. In this way the field-dependent and the field-constant aberrations can be corrected [21]. Similarly, Zernike aberrations in the system with and without freeform contributions are investigated for the on-axis field point.
In case of the folded NPP configuration, differently than for the system with only one freeform, the system is strained by large compensating contributions of primary aberrations generated at the second and at the third mirror; see Figure 4-7. It is interesting to notice that in absence of the freeform contribution at the second mirror the induced trefoil component from the third mirror disappears. This phenomenon is assigned to the reduction of incoming astigmatism. However, due to nearly collimated beam after reflection from the second mirror (small slope of the marginal ray $u'$), the large astigmatism contribution does not significantly influence the intrinsic components of trefoil and Zernike secondary astigmatism. In turn, the large contribution of Zernike astigmatism from the third mirror of the opposite sign increases the intrinsic trefoil component. Consequently, the correction of the trefoil in the exit pupil is obtained from the balance of the positive induced and the negative intrinsic components. In analogy, the incoming coma and astigmatism of opposite signs generate the induced secondary Zernike astigmatism component at the third mirror. It is further balanced out by the intrinsic component resulting from the inverted relation between the primary aberration contributions of the third mirror.
Figure 4-7. Zernike aberrations of the NPP folded configuration. (a) Zernike astigmatism (Z5) and Zernike coma (Z8) surface contributions generated in the system with freeform sag contributions added at M2 and M3, (b) trefoil (Z11) and Zernike secondary astigmatism components generated in the system with freeform sag contributions added at M2 and M3, (c) Zernike astigmatism (Z5) and Zernike coma (Z8) surface contributions generated in the system with freeform sag contribution subtracted from M2, (d) trefoil (Z11) and Zernike secondary astigmatism components generated in the system with freeform sag contribution subtracted from M2, (e) Zernike astigmatism (Z5) and Zernike coma (Z8) surface contributions generated in the system with freeform sag contribution subtracted from M3, (f) trefoil (Z11) and Zernike secondary astigmatism components generated in the system with freeform sag contribution subtracted from M3.

As the second possible solution, the “zigzag” PNP configuration was studied; see Figure 4-8. Similarly as in case of the system with one freeform element, the impact of the two freeform elements on the redistribution of primary aberrations is not significant. The subtraction of the freeform sag from the second mirror increases Zernike astigmatism that disturbs
the correction of trefoil through both; the increase of the negative intrinsic component from the second mirror and the increase of the positive induced components from the second and the third mirrors. Consequently, the balance in the exit pupil is disturbed. Minor change of Zernike astigmatism caused by the subtraction of the freeform sag from the third mirror has nearly no influence on the correction of trefoil. The small contribution of coma and the converging outgoing marginal ray at the third mirror result in Zernike secondary astigmatism being generated only at the third mirror. Thus, the correction of Zernike secondary astigmatism remains nearly unaffected.
To validate the analysis of aberrations of the central field point for the full FOV, the FFDs of the trefoil and Zernike secondary astigmatism components in the exit pupil are generated; see Figure 4-9. The homogeneous distribution of the aberration components over the considered small FOV is noticed. The only deviation results from the presence of the Zernike aberration terms Z10 and Z13 in case of field points with non-zero $H_x$ coordinate. Thus, the observed relations between the low- and higher-order aberrations are valid for the complete FOV. In case a larger FOV is considered and freeform elements are placed away from the stop, aberration fields become field-dependent and field points have to be analyzed separately.

The relations between aberrations presented above cannot be easily identified using classical performance metrics like the spot size RMS or the Zernike coefficients in the exit pupil. The analysis of the Zernike aberration components is therefore a powerful tool in determining differences between configurations [51].
4.2.3 Performance comparison

In order to supplement the aberration analysis, auxiliary performance criteria for both down-selected TMA configurations are introduced. To sum up the analysis of the previous subsection, the spot size RMSs for 0 deg field angle are listed in Table 4-2. Additionally, to carry out the misalignment sensitivity analysis, the tilt error of 0.1 deg is introduced to the first and separately to the second mirror without decentering the subsequent surfaces and the resulting spot size RMSs are evaluated. Further, two supplementary criteria, namely peak-to-valley (P-V) of the freeform sags without the rotationally symmetric part and volumes of the systems are compared.

Table 4-2. The comparison of TMA configurations in terms of the auxiliary performance criteria

<table>
<thead>
<tr>
<th>Criterion</th>
<th>NPP folded</th>
<th>PNP “zigzag”</th>
</tr>
</thead>
<tbody>
<tr>
<td>0° field angle [spot RMS]</td>
<td>4.5 μm</td>
<td>1.5 μm</td>
</tr>
<tr>
<td>0.1° tilt error of M1 [spot RMS]</td>
<td>4.8 μm</td>
<td>2.5 μm</td>
</tr>
<tr>
<td>0.1° tilt error of M2 [spot RMS]</td>
<td>13.9 μm</td>
<td>2.4 μm</td>
</tr>
<tr>
<td>Volume of the system</td>
<td>2.06 dm³</td>
<td>0.34 dm³</td>
</tr>
<tr>
<td>Freeform sag at M2 [P-V]</td>
<td>410 μm</td>
<td>9 μm</td>
</tr>
<tr>
<td>Freeform sag at M3 [P-V]</td>
<td>430 μm</td>
<td>7 μm</td>
</tr>
</tbody>
</table>

The results of Table 4-2 confirm the results of analysis from Subsection 4.2.2 and therefore the PNP “zigzag” configuration appears as a better solution for the TMA system with the small FOV. It is characterized by smaller RMS of the spot size, smaller volume and smaller P-V values of the freeform sag contributions, which reduces manufacturing costs. It is further noticed that the PNP “zigzag” configuration is less sensitive to the tilt error of the second mirror. This correlates with the P-V values of the freeform sag contribution from the third mirror.

Congruent results pointing out the “zigzag” geometry as the best-performing solution for the freeform TMA system with PNP configuration were obtained from the aberration analysis based on NAT [22].
4.3 Selection of the surface

In the following subsection, the design strategy based on assessing the potential of a studied system for simultaneous correction of low- and higher-order Zernike aberrations is utilized to select the most effective surface for adding the freeform sag contribution. The plane-symmetric, three-mirror system without field and with the $F = 5$ is investigated. The system consists of concave mirrors with equal optical powers. Two ray-tracing directions are considered; initial, from infinite object to finite image (I-F) and reversed, from finite object to infinite image (F-I); see Figure 4-10.

![Figure 4-10](image.png)

Figure 4-10. The layouts of the analyzed three-mirror system; (a) with the initial ray-tracing direction from infinite object to finite image space (I-F), (b) with the reversed ray-tracing direction from finite object to infinite image space (F-I).

Since all mirrors have equal optical powers and are tilted by the same angle, the performance limiting aberration is accumulated Zernike astigmatism. As known from Seidel theory (see Subsection 2.1.4), in such system the contributions of primary astigmatism from each surface are of similar sign and magnitude independently of the ray-tracing direction; see Figure 4-11.
However, the distribution of the higher-order Zernike aberrations depends on the slope of the outgoing marginal ray (see Section 4.1) and therefore differs for each ray-tracing direction. Thus, the components of trefoil, which is the dominant higher-order aberration, are studied; see Figure 4-12.

The configuration with the initial ray-tracing direction (I-F) generates large components of trefoil at the last mirror and is not corrected for that aberration in the exit pupil. In contrary, in case of the reversed ray-tracing direction, the generated components of trefoil are less prominent resulting in the smaller contribution to the total wave aberration. This is assigned to the differences in the slope of the outgoing marginal ray. If the beam reflected from the mirror is converging, the intrinsic trefoil term is larger than in case of a collimated reflected beam. Consequently, in case of the initial ray-tracing direction, the marginal ray is converging after the first and the last mirrors generating larger intrinsic components of trefoil. Since initial
systems are strongly aberrated, the evaluation of the induced effect is less accurate due to the large pupil mapping error.

In the next step the freeform sag contribution, described with the low-order Zernike fringe terms 5, 8 and 9, is placed respectively at the position of each mirror, giving in total six configurations. It is clear that in order to correct the aberrations of the system, the freeform element has to compensate for the sum of Zernike astigmatism from two remaining mirrors. As stated before this can be obtained independently of the position of the freeform in the system does not depend on the ray-tracing direction. Thus, there are three possible distributions of primary Zernike astigmatism in the system with the freeform element; see Figure 4-13.

![Figure 4-13](image)

Figure 4-13. The distributions of primary Zernike astigmatism in the analyzed three-mirror system with the freeform element in three different configurations; (a) freeform-spherical-spherical (FSS), (b) spherical-freeform-spherical (SFS), (c) spherical-spherical-freeform (SSF).

However, the comparison of the RMS spot size values shows that depending on the direction of the ray trace, the suitable position of the freeform element to improve the imaging performance differs; see Figure 4-14. In case of the initial beam path (I-F), the system is best performing with the freeform at the first surface, whereas after reversing the ray-tracing direction the system is better corrected when freeform is placed at the last mirror.
The analysis of the trefoil components in two essentially differing configurations with the freeform at the first (FSS) and at the last (SSF) mirrors, and considering both directions of the ray trace, provides insights to understand the difference in imaging performance; see Figure 4-15. It is noticed that in case of the initial ray-tracing direction, which is worse corrected for trefoil, placing freeform early in the system results in decreased astigmatism incoming on the third mirror. Consequently, due to the converging path of the outgoing marginal ray, the induced trefoil component from the third mirror is reduced and the system is corrected for trefoil in the exit pupil. Incoming astigmatism is not influenced if the freeform is placed at the last mirror. Thus, the induced trefoil component from the third mirror remains significant and changes the sign following the change of the Zernike astigmatism contribution. In contrary, in case of the reversed ray-tracing direction (F-I) residual trefoil in the system without a freeform is small. This is preserved when the freeform element is placed at the third mirror, where only the intrinsic trefoil component from the last mirror is insignificantly changed.
Figure 4-15. The distributions of the trefoil components in the analyzed three-mirror system in four down selected cases; (a) I-F FSS, (b) I-F SSF, (c) F-I FSS, (d) F-I SSF.

In the next step, the results are validated for the system with the similar layout and F# decreased to 2. In order to obtain a well-corrected system, the freeform sag contribution is described with the Zernike terms from 5 to 36. Thus, the correction of both the low- and higher-order aberrations is addressed in the description of the freeform sag contribution. Interestingly, the comparison of the RMS spot size values shows exactly the same result as in case of the system with F# of 5. In case of the initial beam path (I-F) the system is best performing with the
freeform at the first surface, whereas after reversing the ray-tracing direction the system is better corrected when freeform is placed at the last mirror; see Figure 4-16.

![Figure 4-16. The RMS spot size values of the analyzed three-mirror system with F# increased to 2, in six resulting cases, varying the ray-tracing direction and the position of the freeform element.](image)

Further, the analysis of the Zernike aberration components in the exit pupil in the four extreme cases, namely; the I-F FSS, the I-F SSF, the F-I FSS, and the F-I SSF is performed; see Figure 4-17. It confirms that despite the fact that all Zernike aberrations can now be directly corrected by the freeform sag contribution, better imaging performance is obtained in configurations that demonstrate the potential for simultaneous correction of the low- and higher-order terms, namely the FSS for the initial ray-tracing direction and the SSF for the reversed one. It is shown that in these cases trefoil is balanced out in the exit pupil with components of much less significant magnitudes resulting in the better corrected and less strained solutions. It is further interesting to note that with a decrease of the F# by the factor of 2.5, the magnitude of the higher-order aberration components in the exit pupil raises approximately by the factor of 20 in strained systems. The decrease of F# generates also other than only intrinsic components of Zernike astigmatism, which therefore cannot be associated only with primary astigmatism.
Figure 4-17. The Zernike aberration components in the exit pupil in the analyzed three-mirror system with F#=2; (a) in the system with FSS configuration and the initial ray-tracing direction (F-I), (b) in the system with SSF configuration and the initial ray-tracing direction (F-I), (c) in the system with FSS configuration and the reversed ray-tracing direction (F-I), (d) in the system with SSF configuration and the reversed ray-tracing direction (F-I).
4.4 Misalignment sensitivity analysis

The misalignment sensitivity analysis is carried out for the three-mirror system with F# of 2 with the initial ray-tracing direction, similar as in the previous section. Additionally, the configurations in which the basic shape of two mirrors with no freeform sag contribution is toroidal instead of spherical are studied. Systems with toroidal mirrors generate less of intermediate primary astigmatism and therefore require less compensation from the freeform element. All six resulting configurations are listed in Table 4-3.

<table>
<thead>
<tr>
<th>Name of the configuration</th>
<th>M1</th>
<th>M2</th>
<th>M3</th>
</tr>
</thead>
<tbody>
<tr>
<td>SSF</td>
<td>spherical</td>
<td>spherical</td>
<td>freeform (spherical basic shape)</td>
</tr>
<tr>
<td>TTF</td>
<td>toroidal</td>
<td>toroidal</td>
<td>freeform (spherical basic shape)</td>
</tr>
<tr>
<td>SFS</td>
<td>spherical</td>
<td>freeform (spherical basic shape)</td>
<td>spherical</td>
</tr>
<tr>
<td>TFT</td>
<td>toroidal</td>
<td>freeform (spherical basic shape)</td>
<td>toroidal</td>
</tr>
<tr>
<td>FSS</td>
<td>freeform (spherical basic shape)</td>
<td>spherical</td>
<td>spherical</td>
</tr>
<tr>
<td>FTT</td>
<td>freeform (spherical basic shape)</td>
<td>toroidal</td>
<td>toroidal</td>
</tr>
</tbody>
</table>

First, in order to assess the manufacturing tolerances of each freeform element, the P-V values of the azimuthal part of freeform sag contributions utilized in each configuration are evaluated; see Figure 4-18. The larger is the deviation of the surface sag from the basic shape, the larger is the sensitivity to manufacturing errors. It is shown that freeform sag contribution is smallest in case of the system with freeform element placed at the first mirror. This corresponds to the result of the previous section, where FSS is the configuration with less significant higher-order Zernike aberration components in the exit pupil. It is also interesting to note that the lower complexity of a freeform element occurs if toroidal mirrors are utilized.
Figure 4-18. The P-V values of the azimuthal part of freeform sag contributions of freeform elements utilized in the six configurations of the three-mirror system.

Further, the tilt tolerances are estimated in the way described in Section 2.5. Thus, the change in the RMS spot size values with respect to the tilt error introduced to each mirror independently are evaluated; see Figure 4-19. Two alignment approaches, with and without decenter compensation, are simulated. From both plots one can see that the tilt error introduced to the last mirror of the system has a similar effect independently of considered configuration and alignment approach. However, the differences are prominent in case of the second and first mirrors. In addition to the error introduced by the mirror, if the tilt error is not compensated by decentering of subsequent mirrors, the beam is reflected from the decentered part of subsequent mirrors leading to the more significant increase in the RMS spot size values.

Figure 4-19. The resulting RMS spot size values after introducing the tilt error to respective mirrors: (a) the alignment approach without decenter compensation, (b) the alignment approach with decenter compensation.

In the next step two configurations with spherical mirrors, which exhibit extreme values of the tilt error on the second mirror are down selected. The smallest sensitivity to the tilt error is obtained in the configuration with the freeform element placed at the first mirror (FSS). The
largest spot error occurs when the freeform is at the last mirror in the system (SSF). In analogy to the Seidel sensitivity parameter (see Section 2.5), the sums of absolute values of Zernike aberrations generated in both unperturbed configurations are shown in Figure 4-20. The SSF configuration generates the larger amount of Zernike aberrations summed over all surfaces and therefore one can expect larger misalignment sensitivities. The aberration contribution from the freeform element is larger and the induced effect is more prominent. This correlates with the comparison of the P-V values. However, it is important to note that this correlation does not necessarily occur if a system consists of elements with different optical powers. In such case freeform sag contribution can be also utilized to reduce the aberration contribution of the surface.

![Figure 4-20](image)

Figure 4-20. The absolute sums of Zernike aberrations generated at each surface and the sum of all Zernike aberrations of the system (last bar); (a) the SSF configuration, (b) the FSS configuration.

In the perturbed system the image performance is deteriorated and therefore the sum of Zernike aberrations is changed; see Figure 4-21. The tilt error of 0.1° introduced to the second mirror affects the aberration sum in both configurations. In the SSF configuration, the imaging performance is deteriorated because of increased aberration contribution from the second mirror. Additionally, if the third mirror is fixed the decenter of the beam is introducing the large change of the aberration contribution from the third surface. This effect is missing if the tilt error in the second mirror is compensated by decentering the third mirror. In turn, if the freeform is placed at the first mirror the aberration effect is much less prominent and not significantly dependent on the alignment approach.
Figure 4-21. The changes of Zernike aberrations sums after introducing the tilt error of 0.1° deg on the second mirror in case of: (a) the SSF configuration without the decenter compensation at the third mirror, (b) the SSF configuration with the decenter compensation at the third mirror, (c) the FSS configuration without the decenter compensation at the third mirror, (d) the FSS configuration with the decenter compensation at the third mirror.

4.5 Analysis of systems with large FOV

In the following section, the functionality of the introduced method in assisting the design process of a refractive system with the freeform element and the large FOV is demonstrated. As an example aberrations of a classical Cooke triplet objective with freeform single lens added for transverse image translation [52] is analyzed; see Figure 4-22. In this approach a single freeform lens is employed to reduce retro-reflection into an axially symmetric objective [53]. In analyzed objective with F_# of 15, the focal length of 100 mm and the FOV of 10 deg, the freeform single lens shifts the center of the image by 10 mm. The freeform sag is obtained with classical optimization procedure and described with Zernike fringe terms up to the 36th term.
The full field display (FFD) of selected Zernike aberration generated at an individual surface is a useful tool in the design process of freeform systems with large FOV; see Subsection 3.4.1. As an example, components of trefoil from the front and rear surfaces of the freeform lens are shown in Figure 4-23. It is noticed that the complete contributions from both surfaces are of opposite sign and therefore compensate each other. The contribution from the front surface is of intrinsic type, whereas the contribution of the rear surface consists of the intrinsic and induced components. The induced component from the rear surface is a metric of the effect of incoming aberrations on the refraction on the surface. Thus, it is an additional design variable that depends on both freeform surfaces.

Consequently, the correction of the freeform in the exit pupil is established due to the balance between three components; see Figure 4-24.
The method can be also utilized to evaluate surface contributions to the maximum distortion in the final image, defined as in Subsection 3.4.2; see Figure 4-25. The final image grid in the analyzed system with the marked location of the most distorted point is shown. Further, the surface contributions to the maximum distortion in the final image plane are demonstrated with the bar plot.

As seen, the correction of the distortion is a result of the compensating effect of the intermediate image grids after refraction on the front and rear surfaces of the freeform lens, that correspond to contributions from surfaces 7 and 8. This can be better illustrated by generating intermediate image grids; see Figure 4-26. Consequently, it can be concluded that the freeform element requires tighter assembly and manufacturing tolerances than the rest of the system.
Figure 4-26. The surface contribution to distortion of the image grid from; (a) surface 7, (b) surface 8.
Chapter 5  Conclusions

In this thesis the novel numerical method for determining surface-by-surface contributions to the total wave aberration was introduced. It utilizes data from tracing multiple ray sets to determine surface contribution further divided with respect to phenomenological origin into intrinsic, induced and transfer components. Each aberration component is determined from a separate set of rays.

The method provides aberration coefficients derived for a single field point. The graphical representation of field dependency is possible with full-field displays. In principle no constraints are placed on the geometry of an analyzed system. However, in this thesis only plane symmetric freeform systems were studied. Additionally, only systems with near-circular apertures were considered. This allowed characterizing the obtained aberration components with Zernike fringe polynomials.

Currently available analytical methods, typically used to analyze wave aberrations are; coefficients derived from NAT for non-axially symmetric systems and coefficients of the wave aberration function expanded to the sixth order. Additionally, optical design programs provide a tool utilizing ray-tracing data to determine the Zernike aberration coefficients in the exit pupil of the system. The presented approach introduces features supplementary to the existing tools, summarized in Table 5-1.
Table 5-1. The list of functionalities of tools for analysis of wave aberrations.

<table>
<thead>
<tr>
<th>Functionality</th>
<th>NAT</th>
<th>The expansion to the sixth order</th>
<th>Zernike coefficients in the exit pupil</th>
<th>Zernike surface contributions</th>
</tr>
</thead>
<tbody>
<tr>
<td>Field-dependency</td>
<td>+</td>
<td>+</td>
<td>-</td>
<td>-</td>
</tr>
<tr>
<td>Non-axially symmetric systems</td>
<td>+</td>
<td>-</td>
<td>+</td>
<td>+</td>
</tr>
<tr>
<td>Surface contribution</td>
<td>+</td>
<td>+</td>
<td>-</td>
<td>+</td>
</tr>
<tr>
<td>Not constrained to expansion order</td>
<td>-</td>
<td>-</td>
<td>+</td>
<td>+</td>
</tr>
<tr>
<td>Division into components</td>
<td>only intrinsic considered</td>
<td>intrinsic, induced</td>
<td>none</td>
<td>intrinsic, induced, transfer</td>
</tr>
</tbody>
</table>

It was demonstrated that the analysis of Zernike surface contributions provides insights into the design process of freeform systems. The design strategy based on identifying relations between low and higher-order Zernike aberrations was formulated. This enables the control of higher-order Zernike aberrations with low-order Zernike-type freeform surfaces by tracking the behavior of aberration components.
Appendix A

Performance comparison of methods allowing for communication between Matlab® and Zemax®

A.1 Possible methods

Presented is the performance comparison of COM and DDE protocols, which allow for two-way communication between Matlab® and Zemax®. Both are applicable with the toolboxes MZCOM (by Norman G. Worku) and MZDDE (by D.Griffith). First is introduced for versions of Zemax® starting with OpticStudio15®, latter is supported for all professional Zemax® versions. COM works only for 64 bit versions of Matlab® whereas DDE works uninterrupted for 32 bit version experiencing connection breaks when used with 64 bit version. Additionally two modes for utilizing COM protocol are compared. The interactive mode placing changes to the currently opened copy of OpticStudio15® and standalone mode that creates the copy of the file in Matlab® (occupies license key) and operates on it.

Firstly, methods are tested for time efficiency in modifying a lens file from Matlab®. Secondly, to find the efficient way for transferring the ray-tracing data of larger number of rays into Matlab® workspace, the COM routine BatchArrayTrace is compared against zArrayTrace .mex file* based on DDE protocol. Finally, combined approaches for two-way communication are tested. These are COM in standalone mode, COM in interactive mode together with .mex64 file and DDE with .mex32. All methods are tested for their speed in exchanging the data between two programs.

* mex files are functions written in C, compiled to be compatible with MATLAB environment.
A.2 Computational speed evaluation

To compare the performance in changing data in Zemax® file, the time required for placing multiple field points in the loop was measured; see Figure A-1. The comparison of two methods operating on currently opened copy of Zemax®, shows that COM interactive mode is significantly slower than DDE link. The performance of standalone COM exceeds both and can be considered as happening with no delay. It nevertheless takes 5 seconds to generate the copy of lens file inside Matlab®. Another disadvantage is that the changes cannot be seen in the Zemax® user interface making it more difficult for controlling and debugging.

![Figure A-1. Comparison of time required to set field points in lens file from Matlab® using different methods.](image)

For reading the ray-tracing data of larger number of rays into Matlab® workspace, the COM routine BatchArrayTrace and zArrayTrace.mex file are compared. This is realized by measuring time required for tracing different numbers of rays to a single surface; see Figure A-2(a). On a logarithmic scale it is shown that the larger the amount of rays the larger is the benefit of using .mex file. Since, for every surface routines have to be called individually the time for tracing 7841 rays (circular grid of 101x101) to different number of surfaces is also tested; see Figure A-2(b). It shows again the superior performance of the .mex file.
Finally the combined approaches were investigated. As the test, the function tracing 7841 rays to 6 surfaces, setting varying number of field points, was run respectively with COM standalone, COM interactive and the .mex file, and DDE with .mex file; see Figure A-3. It shows that the most efficient combination is the last one. However, it has to be noted that it is only stable when used with the 32 bit version of Matlab®. If 64 bit version of Matlab® is used, combination of the COM interface in the interactive mode for setting field points and .mex file for importing ray tracing data, seems to be the best choice. It is impossible to use the .mex file with COM in standalone mode. Thus, BatchArrayTrace routine is the only choice for tracing large number of rays. Consequently, this is the combination with the poorest performance.
Figure A-3. Performance comparison for tracing 7841 rays to 6 surfaces, setting a varying number of field points. Tested approaches are COM standalone, COM interactive and the .mex file, and DDE with .mex file both on 32bit Matlab®.

Presented investigation of the performance of different methods for two-way communication between Matlab® and Zemax® shows the advantage of using the old DDE communication protocol and the .mex file. However, it is important to note that DDE connection is stable only with 32bit version of Matlab®. If 64bit version is used together with OpticStudio15® or newer version of Zemax®, the COM in interactive mode seems to be the best choice. For reading the ray tracing data into Matlab® the zArrayTrace.mex shows the best performance leaving COM routine BatchArrayTrace far behind. The COM in standalone mode has an advantage of placing changes to the copy of OpticStudio® in real time. Nevertheless it requires 5 seconds to first generate the copy and it occupies the license key. If standalone mode is used for reading out the ray tracing data the only possibility is to use BatchArrayTrace routine which is slower than the .mex file.
References


Acknowledgements

This research was partially founded by the German Federal Ministry of Education and Research with the project fo+ (FKZ: 03WKCK1D).

I would like to thank Prof. Herbert Gross for giving me the opportunity to work on the topic of wave aberrations to which I was keen to contribute and for the possibility to participate in international conferences.

I also acknowledge again my supervisor Prof. Herbert Gross and Dr. Ralf Hambach for help in formulating the ideas of this thesis through many scientific discussions.

Thanks to my great officemate Christoph Bösel. I have appreciated all of our discussions and companionship throughout the years. I am grateful to my group members for creating a pleasant working atmosphere occasionally distracted by sharing a piece of cake.

I would like to thank my classmates from Master in Photonics Program who were the people I first met after coming to Jena, especially; Can Boran Akdal, Dr. Lorenz von Grafenstein, Franck Gounou, Dr. Samuel Serna.

I would also like to thank numerous fellow scientists scattered around the Beutenberg campus for their friendship; Dr. Pol Ribes, Sophie Sauva, Dr. Lilía Espada, Dr. Pol Alonso, Lorena Halty, Dr. Oscar Gutierrez, Dr. Ilona Koebsch, Dr. Rossa Mac Ciamain, Marta Kazimierska, Tobias Tieß, Agnieszka Litomska, Asya Martirosyan, Sean Garnsey, Marta Gilaberte, Dr. Shu Zhe, Florencia Campetella, Aoife Brady and many others who I met during the time of my Phd work. In particular, I would like to thank Laura Keys for her companionship and understanding.

And lastly, I am grateful to; my parents, sister Dorota and cousin Lukasz, with his wife Asia, and to my oldest niece Lena for their unconditional support that has contributed to the completion of this thesis.
This page is left blank intentionally.
Zusammenfassung


This page is left blank intentionally.
Curriculum Vitae

Oleszko, Mateusz

Date of birth: 10.07.1988
Location of birth: Opole, Poland

09.1995 – 07.2001 Public Primary School No. 14, Opole, Poland
09.2001 – 07.2004 Public Middle School No. 9, Opole, Poland
09.2004 – 04.2007 Secondary Education Public High School No. 3, Opole, Poland
10.2007 – 01.2011 Bachelor of Engineering in Applied Physics Politechnika Wrocławska, Wrocław, Poland
10.2011 – 04.2014 Master of Science in Photonics Friedrich-Schiller-Universität, Jena, Germany
07.2014 – 08.2018 Ph.D. Candidate Institut für Angewandte Physik, Friedrich-Schiller-Universität, Jena, Germany

Jena, 05.11.2018

Signature
This page is left blank intentionally.
Publications

Journal articles


Conference proceedings

This page is left blank intentionally.
Ehrenwörtliche Erklärung

Ich erkläre hiermit ehrenwörtlich, dass ich die vorliegende Arbeit selbständig, ohne unzulässige Hilfe Dritter und ohne Benutzung anderer als der angegebenen Hilfsmittel und Literatur angefertigt habe. Die aus anderen Quellen direkt oder indirekt übernommenen Daten und Konzepte sind unter Angabe der Quelle gekennzeichnet.

Bei der Auswahl und Auswertung folgender Materials haben mir die nachstehend aufgeführten Personen in der jeweils beschriebenen Weise unentgeltlich geholfen:

- Herbert Gross, Betreuer.


Die Arbeit wurde bisher weder im In- noch im Ausland in gleicher oder ähnlicher Form einer anderen Prüfungsbehörde vorgelegt.

Die geltende Promotionsordnung der Physikalisch-Astronomischen Fakultät ist mir bekannt.

Ich versichere ehrenwörtlich, dass ich nach bestem Wissen die reine Wahrheit gesagt und nichts verschwiegen habe.

Jena, 05.11.2018

Unterschrift d. Verfassers